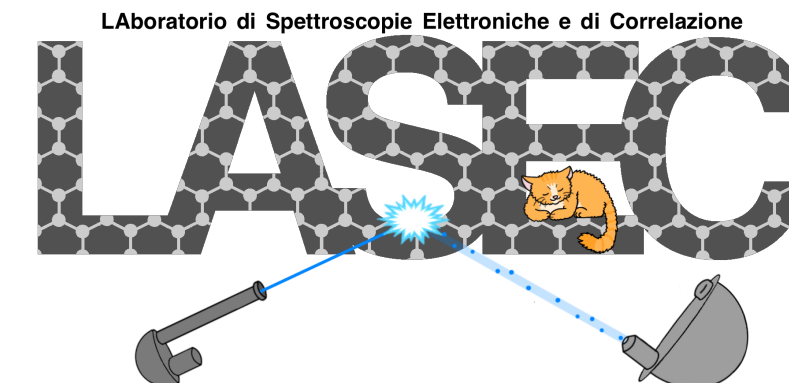


# Transmission through graphene of electrons in the 30 - 900 eV range

Alice Apponi, Domenica Convertino, Neeraj Mishra,  
Camilla Coletti, Mauro Iodice, Franco Frasconi, Federico  
Pilo, Gianluca Cavoto, Alessandro Ruocco

Ptolemy collaboration meeting

06 - 07 October 2022 / Zandvoort, NL



SAPIENZA  
UNIVERSITÀ DI ROMA

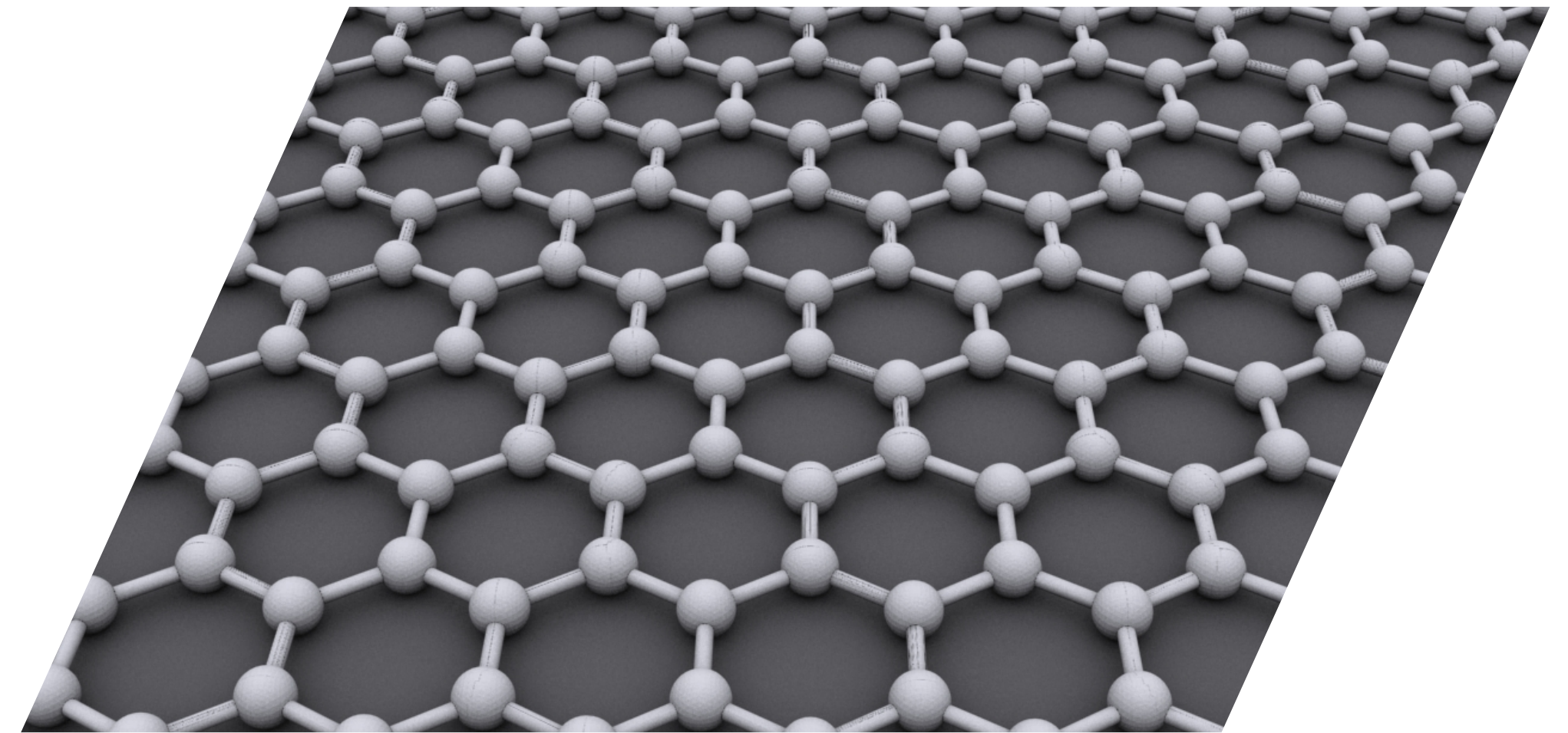


ISTITUTO ITALIANO  
DI TECNOLOGIA  
GRAPHENE LABS

# Graphene transparency: a growing topic of interest

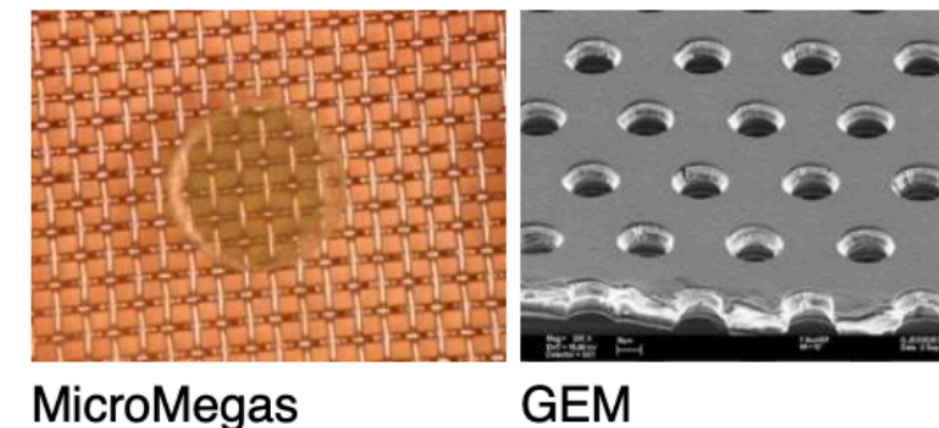
Graphene:

- ❖ Single sheet 1 atom thick
- ❖ C atoms  $sp_2$  hybridised (planar,  $120^\circ$ ) arranged in hexagons



Transmission of low-energy electrons through graphene:

- ❖ Many experiments several electron energy ranges
- ❖ Only a few below 1 keV
- ❖ Discussion still open
- ❖ Interesting for novel detectors



Integration of graphene in MPGD  
Transparency to electrons  
Impermeability to atoms



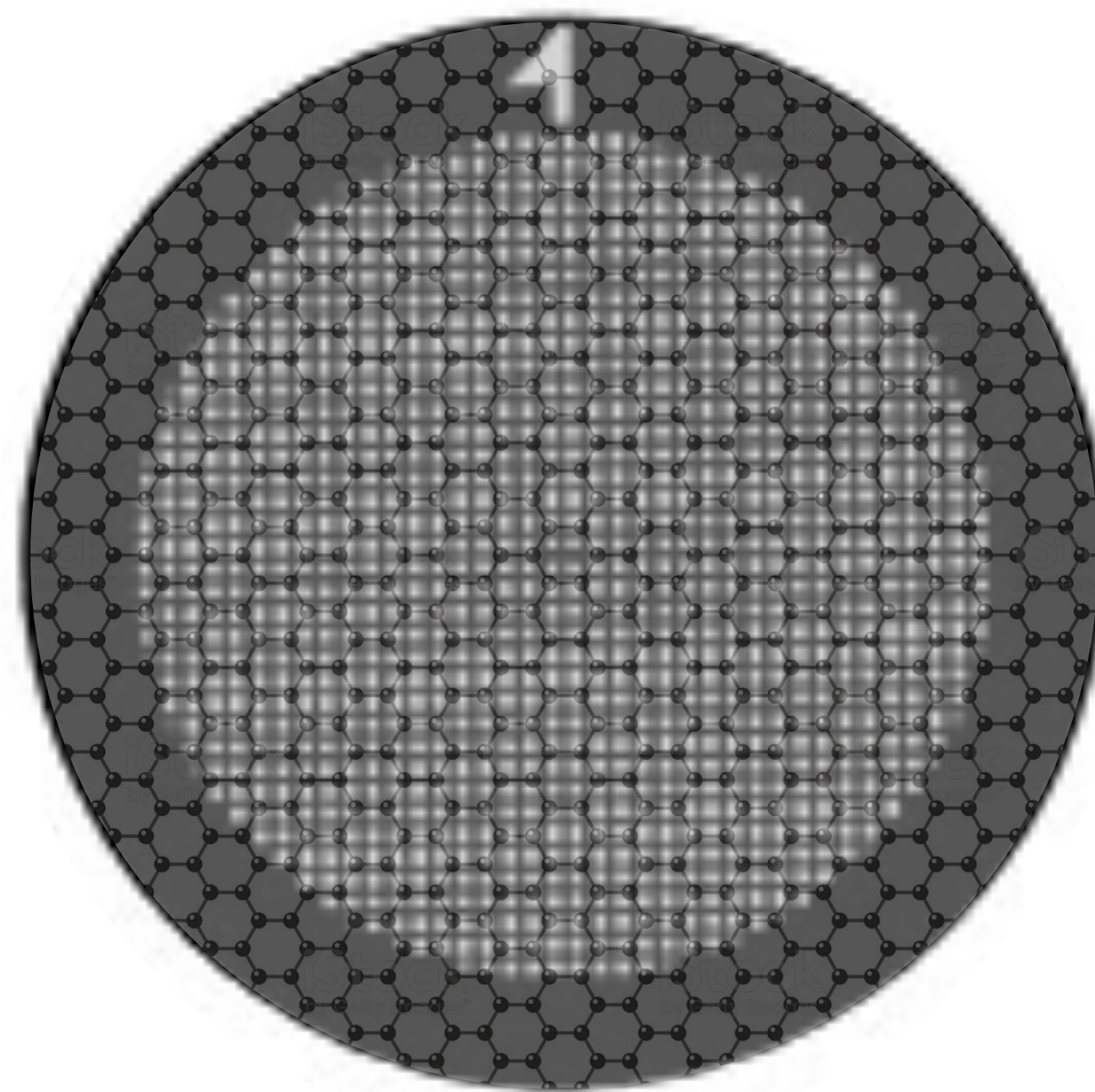
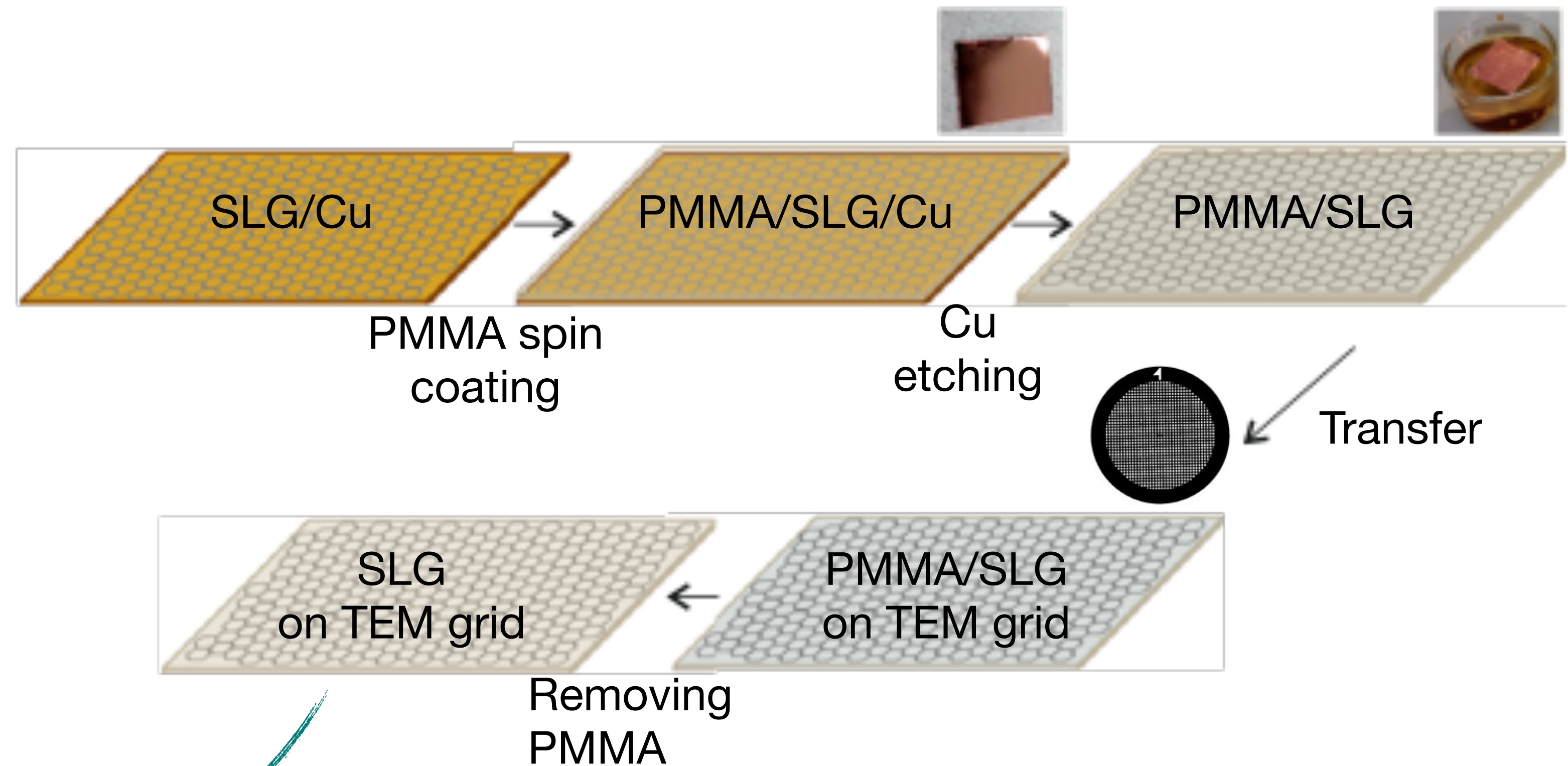
Tritiated graphene target  
Measure the  $\beta$ -electrons



# Sample preparation: graphene growth and transfer on TEM grid

Mono-/tri- layer graphene on nickel TEM grid:

- ❖ G2000HAN - Ted Pella Inc.
- ❖ 2000 mesh per inch  $\rightarrow$   $12.5\ \mu\text{m}$  pitch
- ❖ Hole width  $6.5\ \mu\text{m}$
- ❖ Nominal geometrical transmission 41%



PMMA = Poly-methyl-methacrylate  $(\text{C}_5\text{O}_2\text{H}_8)_n$

**Camilla Coletti talk tomorrow**

# Measurements of graphene on TEM grids

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Graphene characterisation with spectroscopy:

- ❖ Micro-Raman
- ❖ X-rays Photoemission Spectroscopy (XPS)
- ❖ Electron Energy Loss Spectroscopy (EELS)



Transmission of low-energy electrons (30-900 eV):

- ❖ Fixed point measurement as a function of the energy

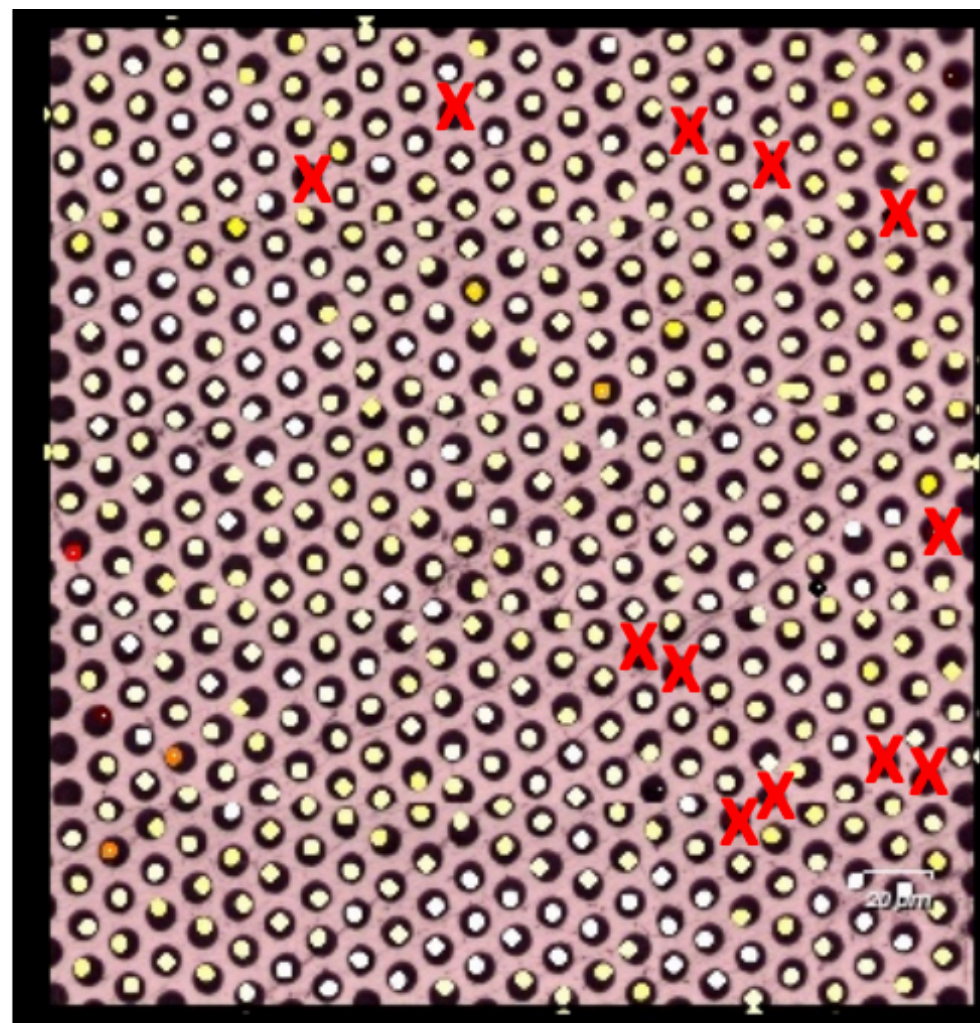


# Raman spectra: full coverage good quality graphene

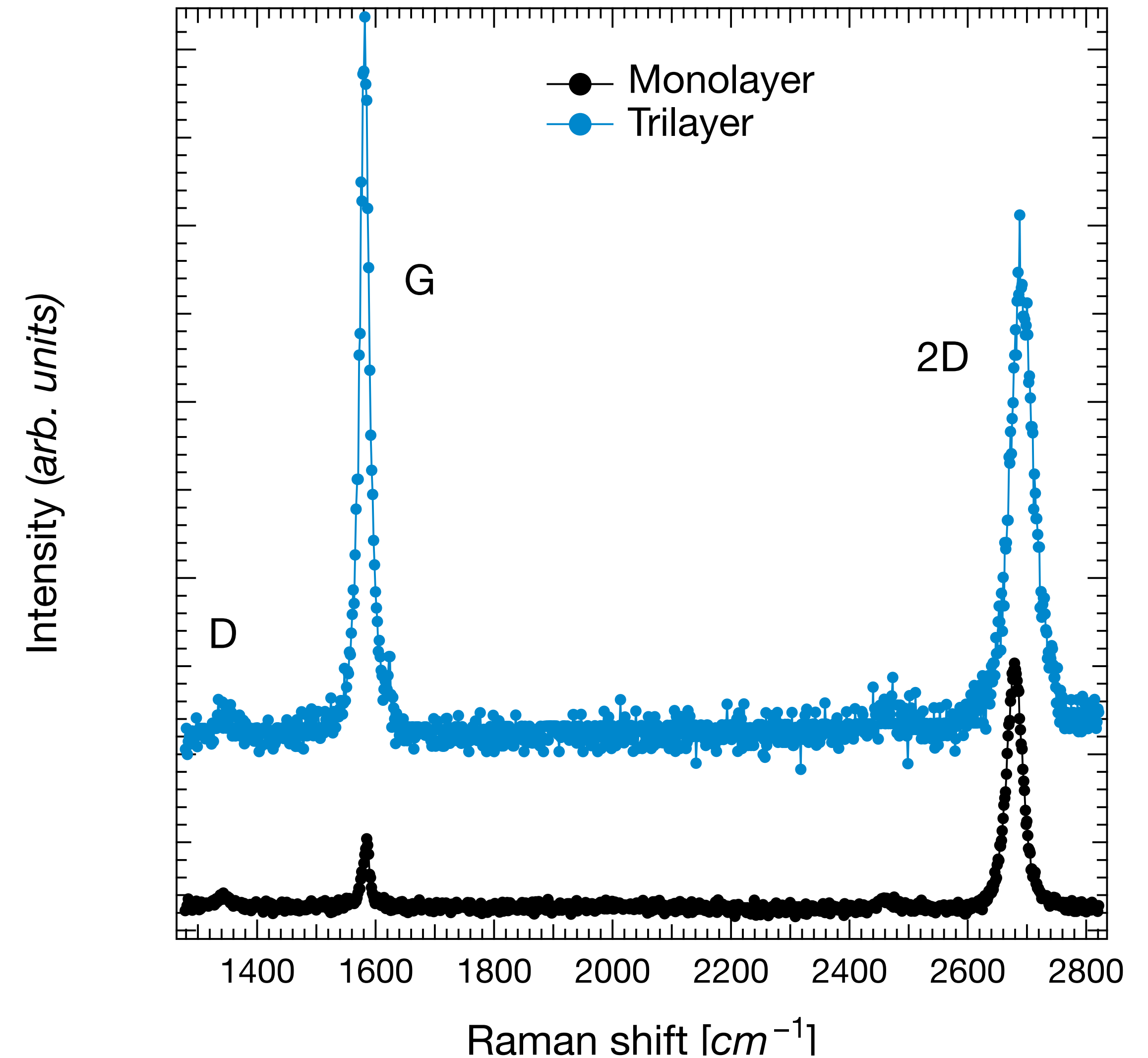
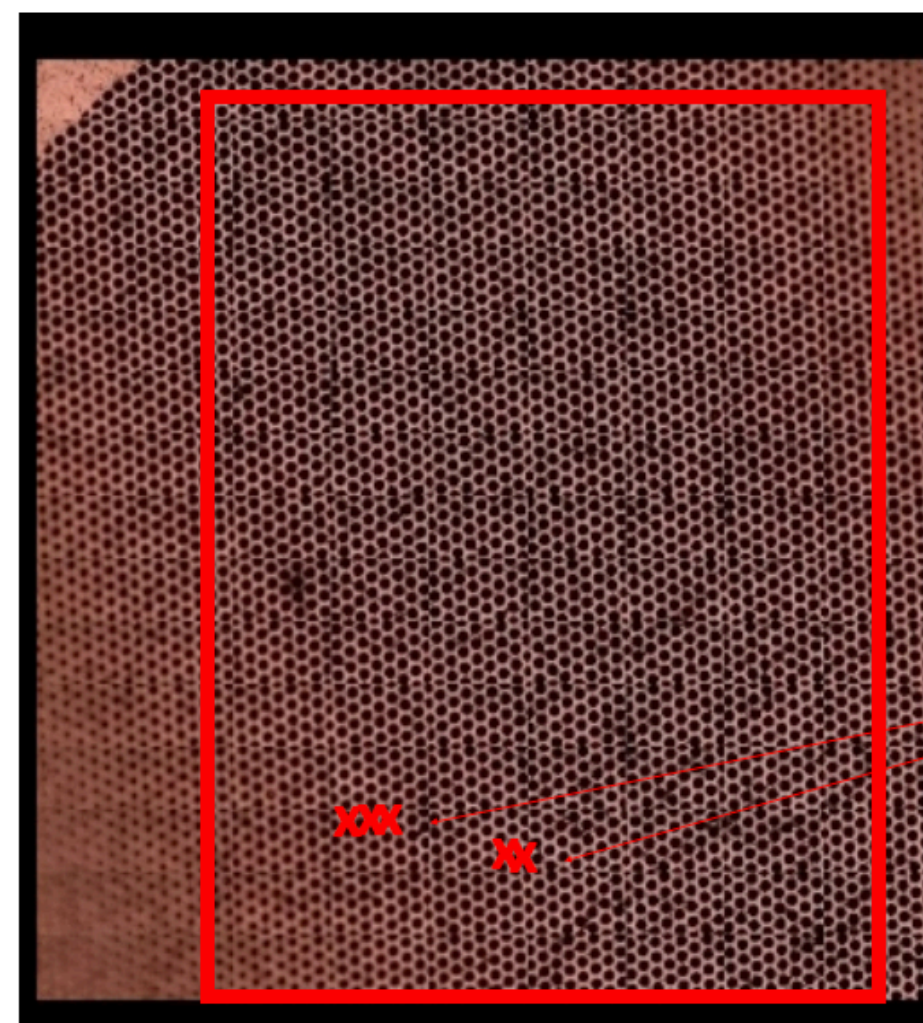
Micro-Raman maps:

- ❖ Full coverage achieved
- ❖ Few spots without graphene X

Monolayer

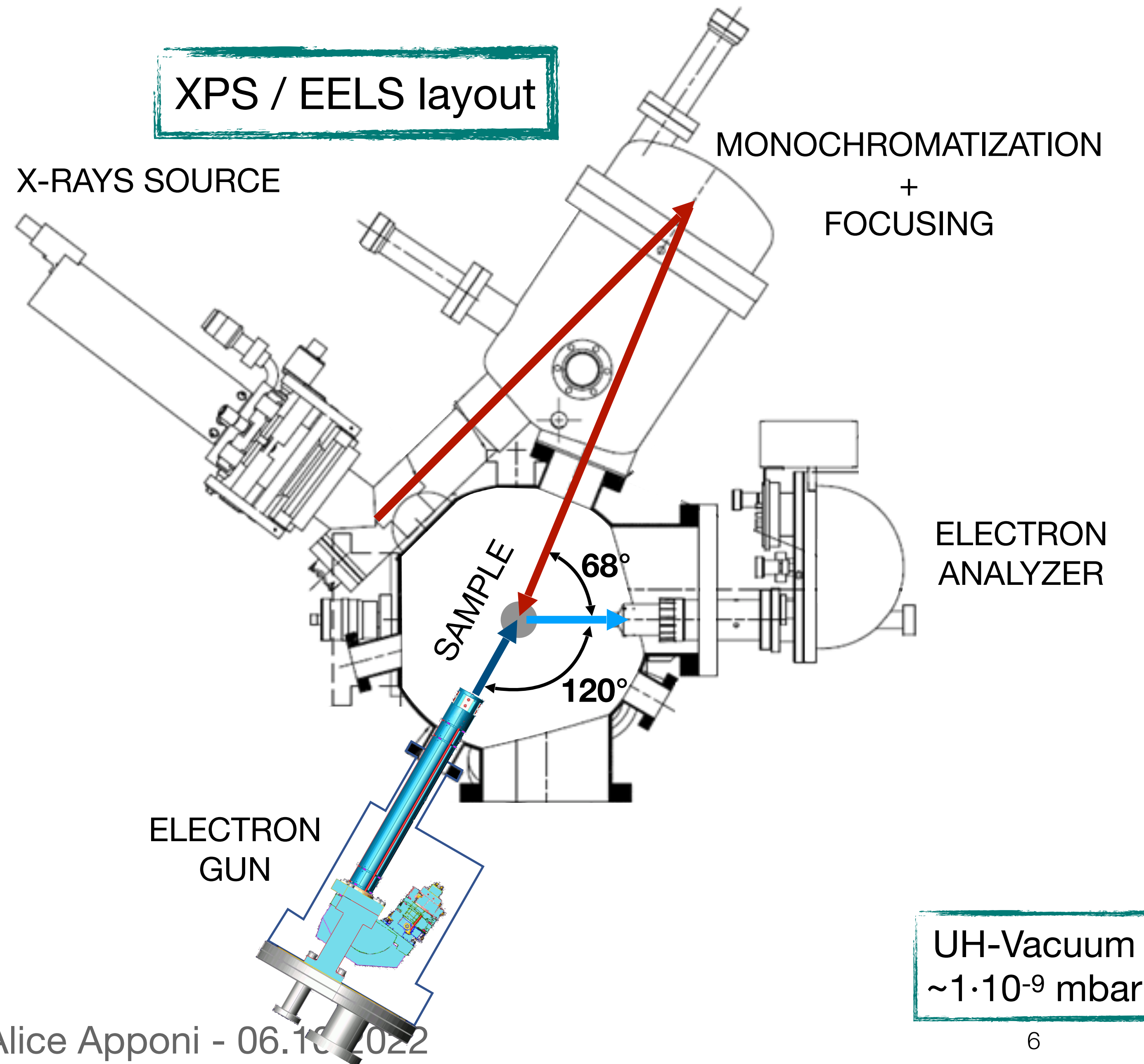


Trilayer





# The LASEC experimental layout



Al  $K\alpha$  source:

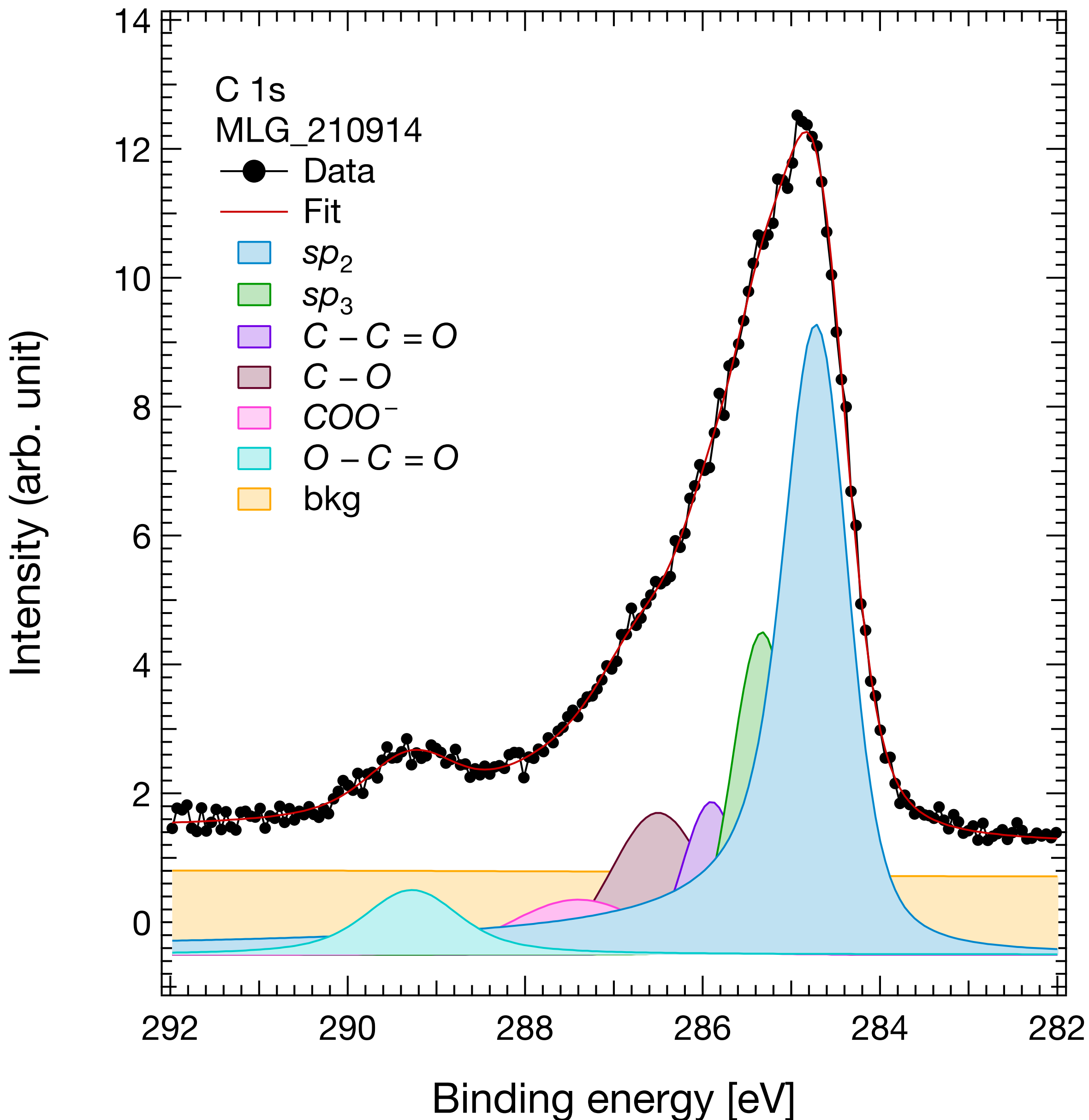
- ❖  $h\nu = 1486.7$  eV
- ❖ Resolution 0.35 eV
- ❖ Analyser wf = 4.3 eV
- ❖ Tot resolution = 0.46 eV

Custom-made monochromatic electron gun:

- ❖ Continuous electron beam
- ❖ Tuneable energy 30 - 900 eV
- ❖ Resolution = 45 meV

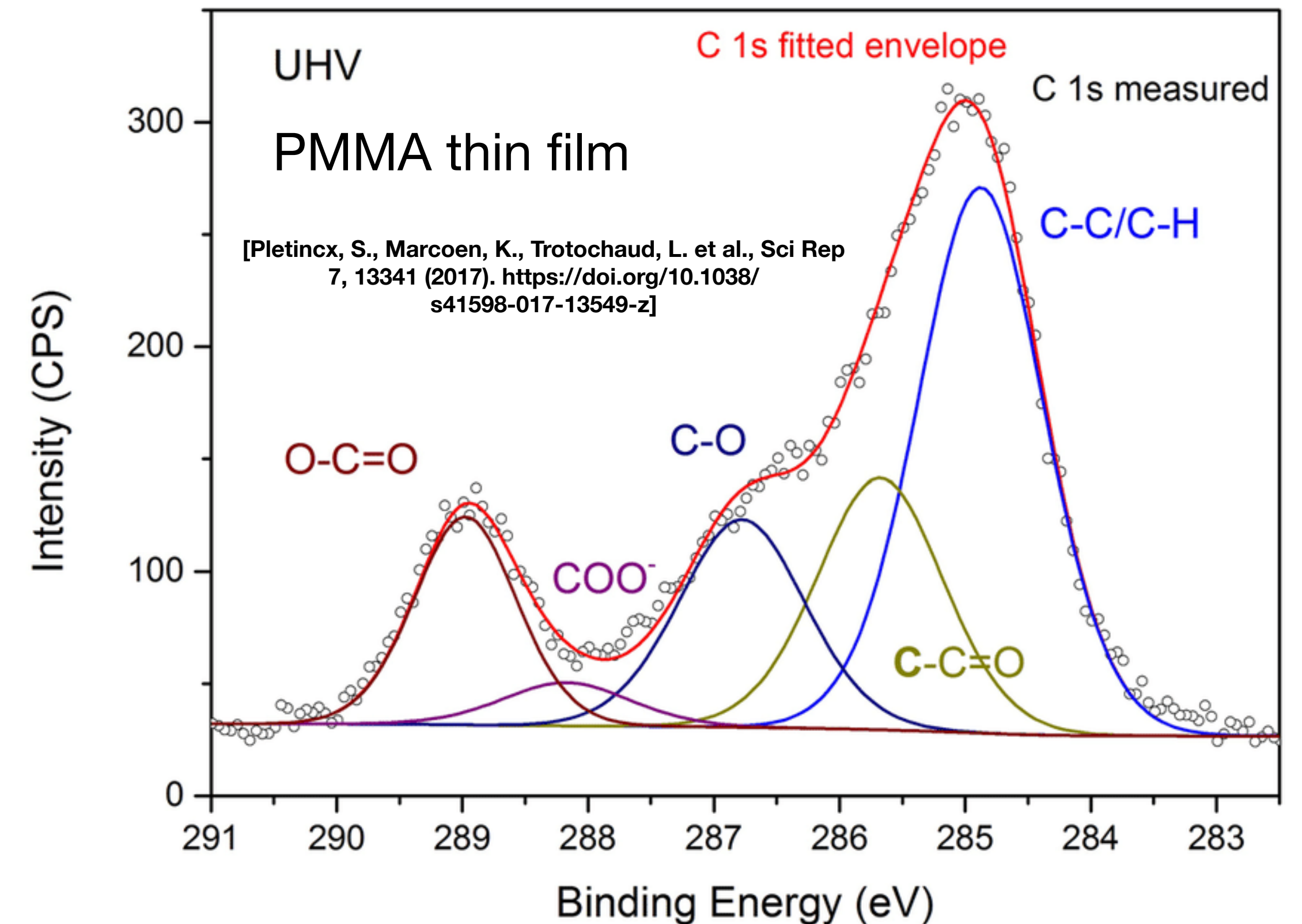


# Monolayer C 1s: high contamination



Monolayer sample measured before annealing:

- ✿ High contamination
- ✿ PMMA residues due to graphene transfer
- ✿ Clean the sample is necessary

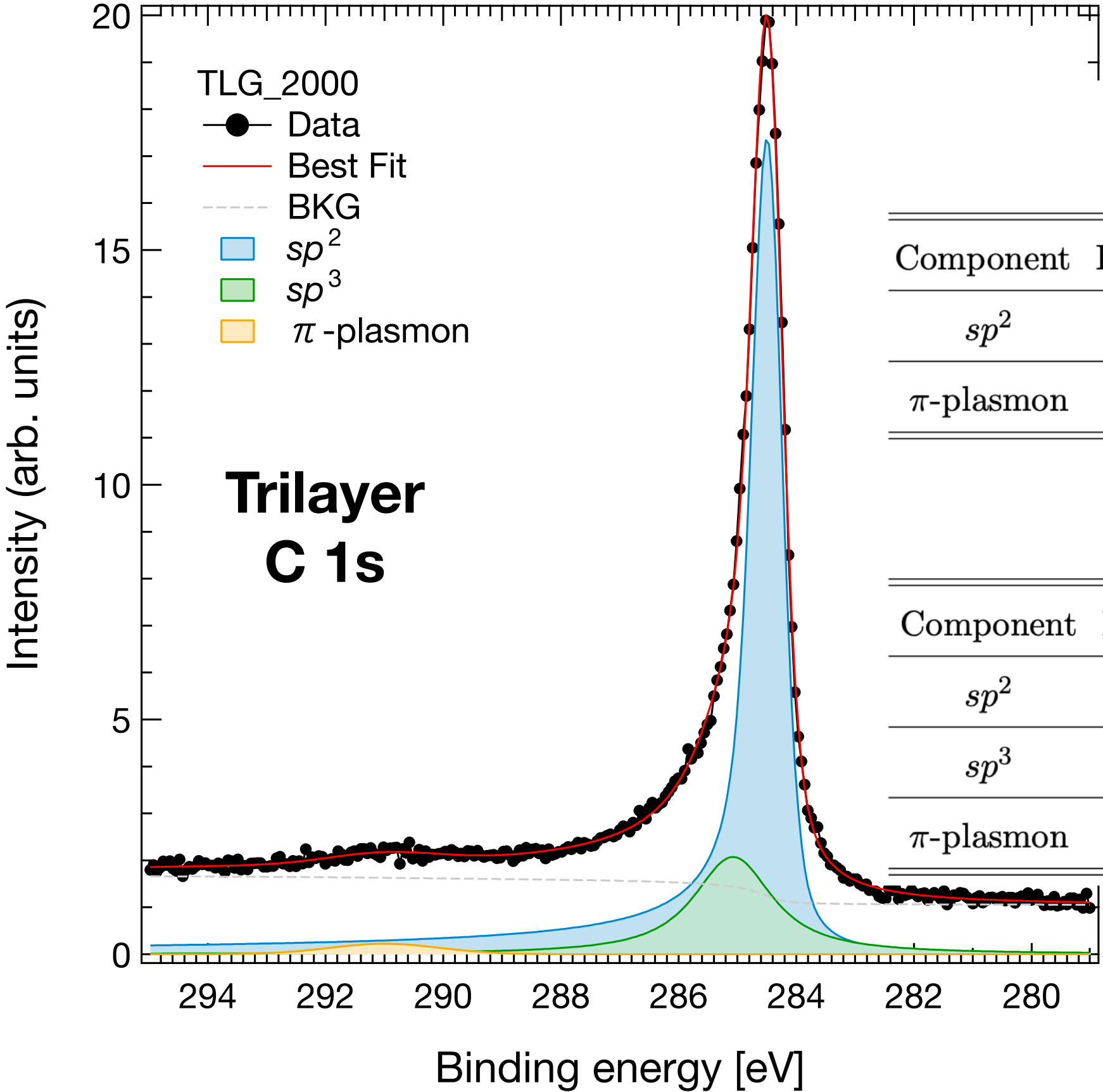
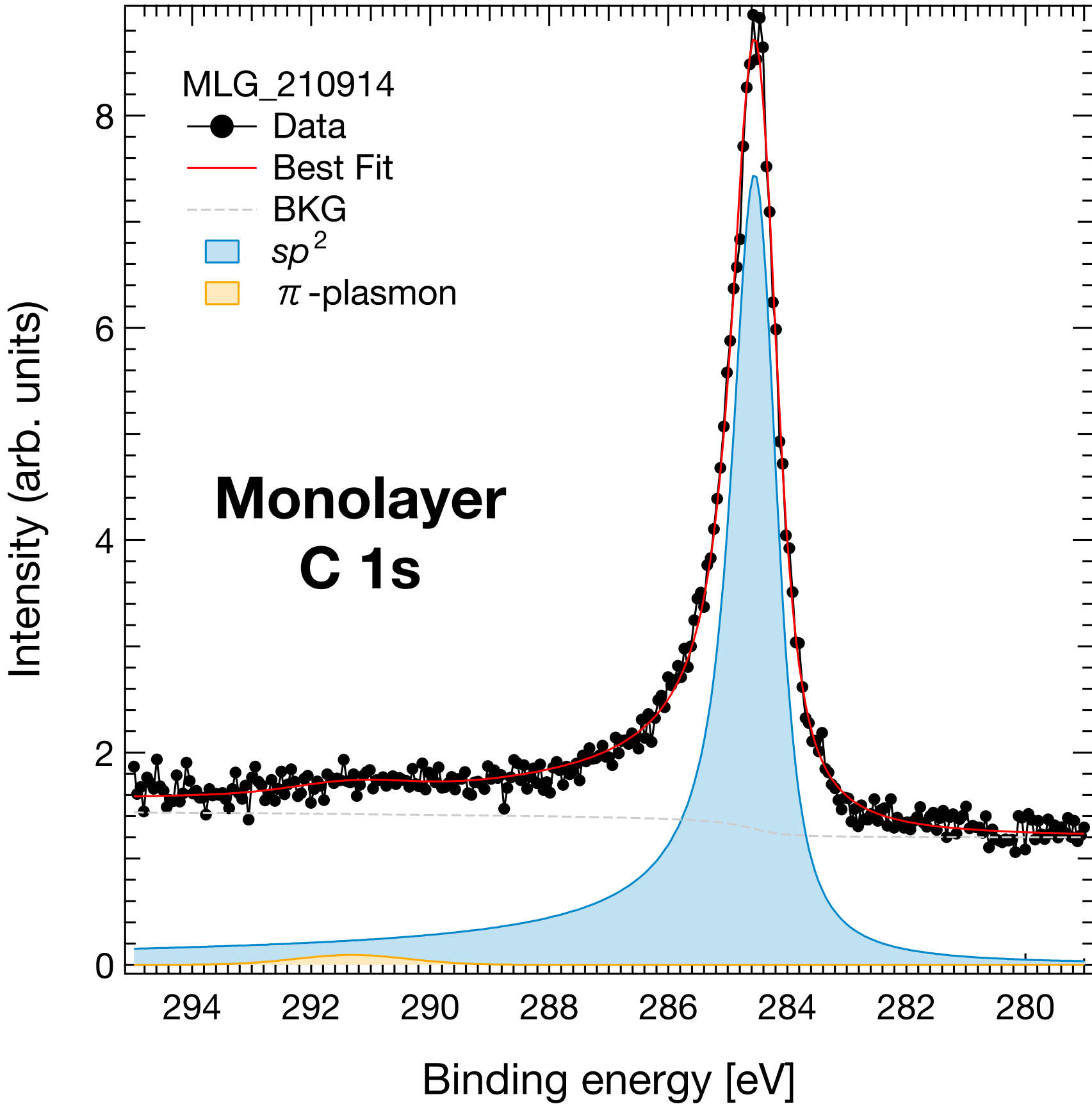
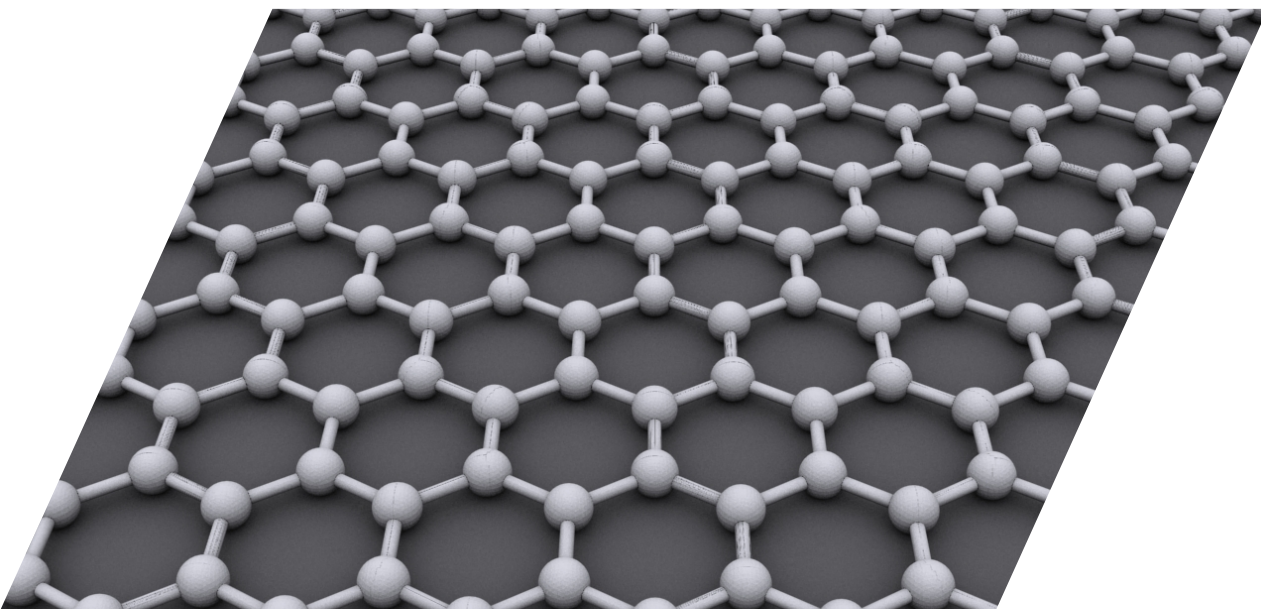


# XPS: good quality graphene

500°C annealing  
in vacuum

Both C 1s spectra reveal a good quality graphene:

- ❖ Main contribution due to  $sp^2$
- ❖ Slight amount (~20%) of  $sp^3$  in the trilayer
- ❖ Lorentzian width of  $sp^2$  higher in the monolayer



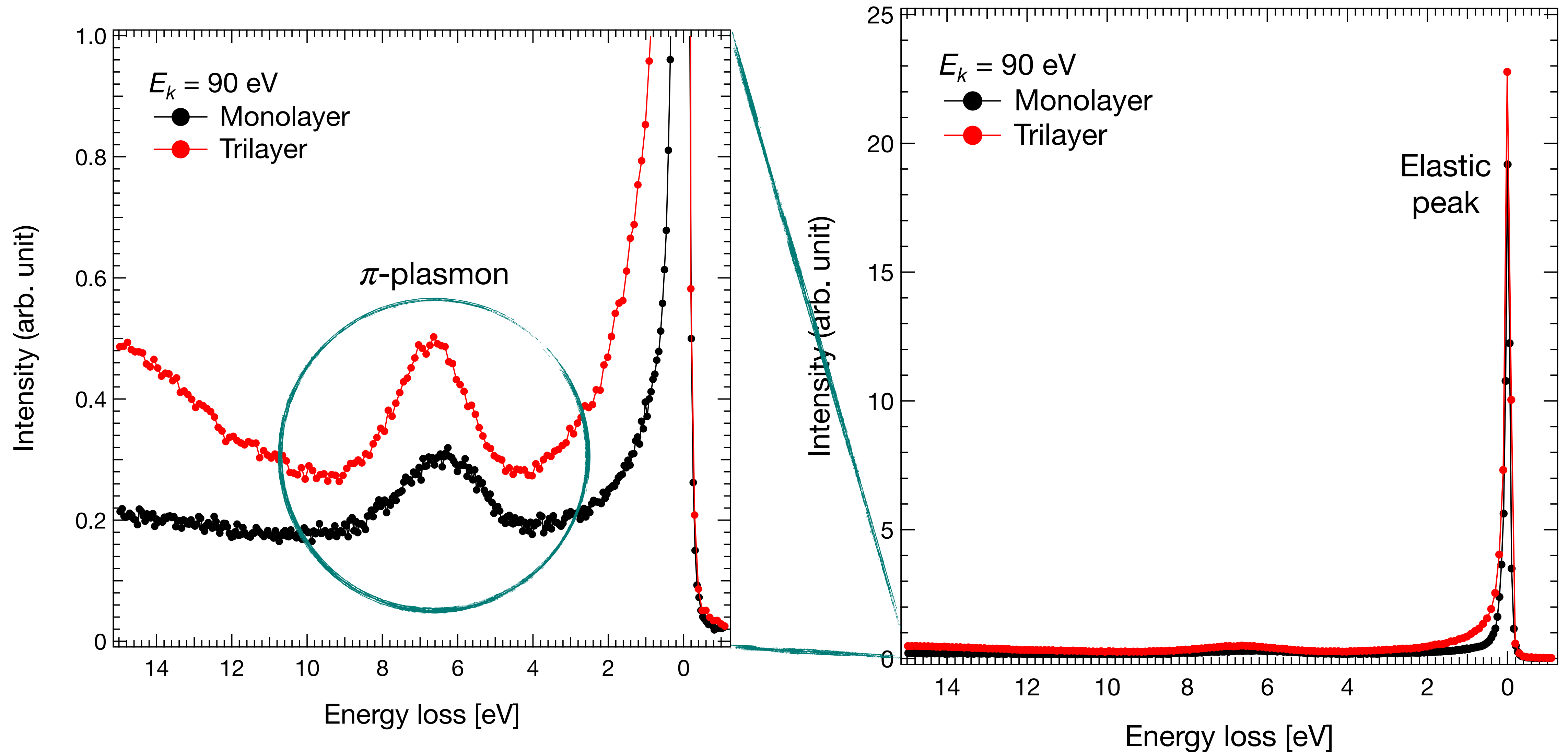
Monolayer graphene					
Component	Binding energy [eV]	Area	GW [eV]	LW [eV]	Asymmetry
$sp^2$	284.45	204	0.45	0.58	0.1
$\pi$ -plasmon	290.9	4	1.9	0	0

Trilayer graphene					
Component	Binding energy [eV]	Area	GW [eV]	LW [eV]	Asymmetry
$sp^2$	284.47	311	0.46	0.24	0.1
$sp^3$	285.1	84	0.5	1.5	0
$\pi$ -plasmon	291.0	10	2.2	0	0

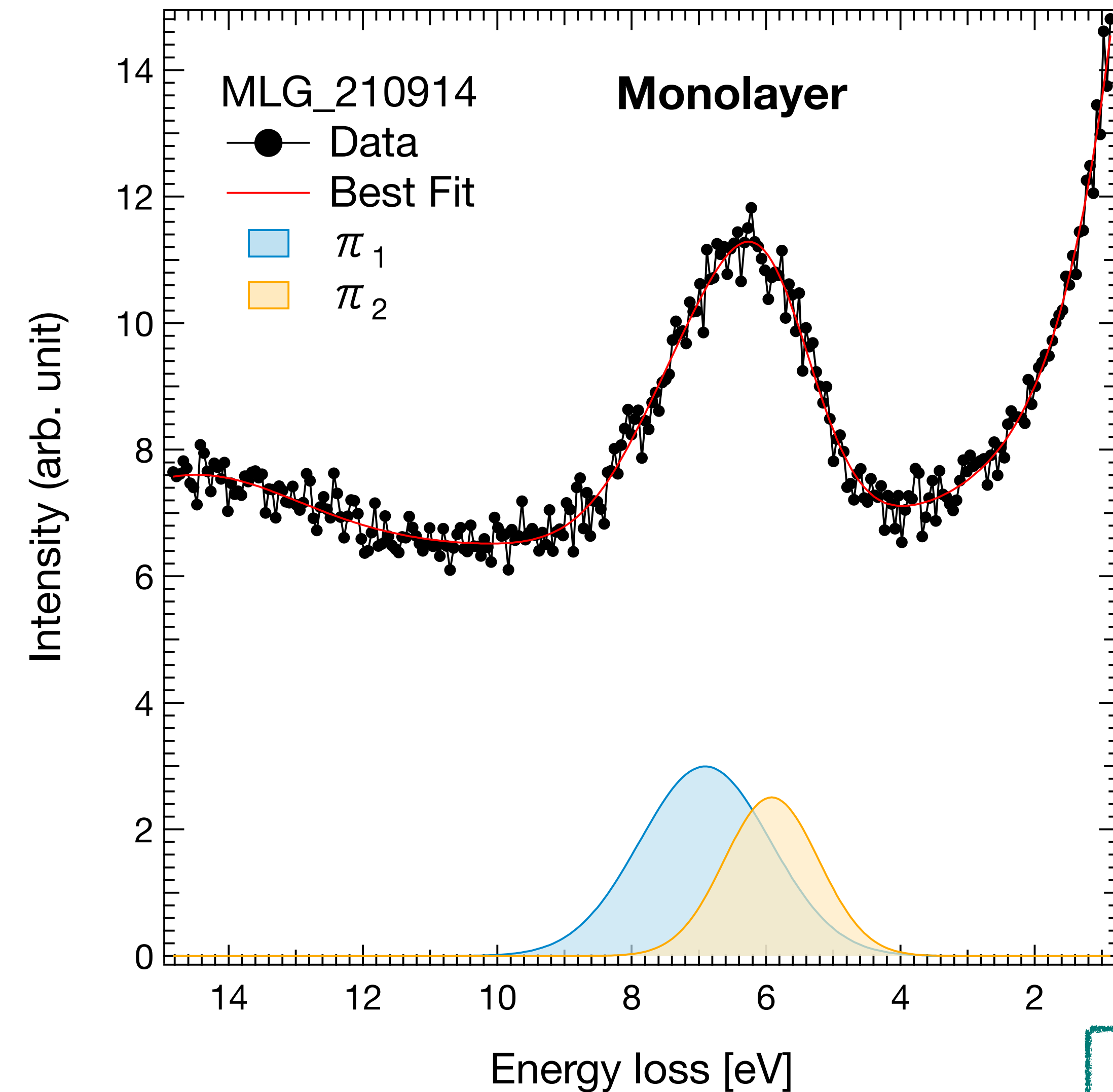


# Comparison of the EELS spectra

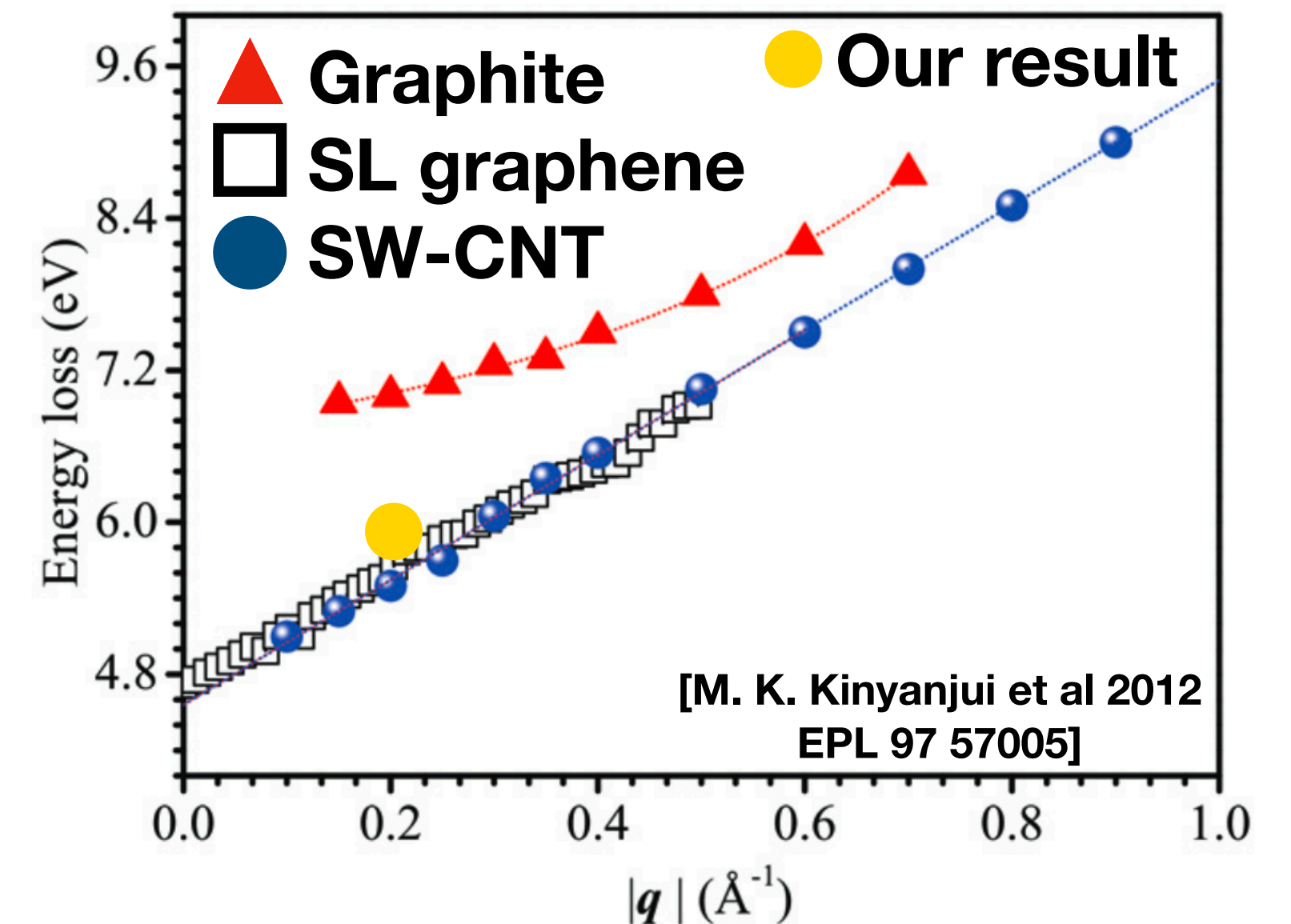
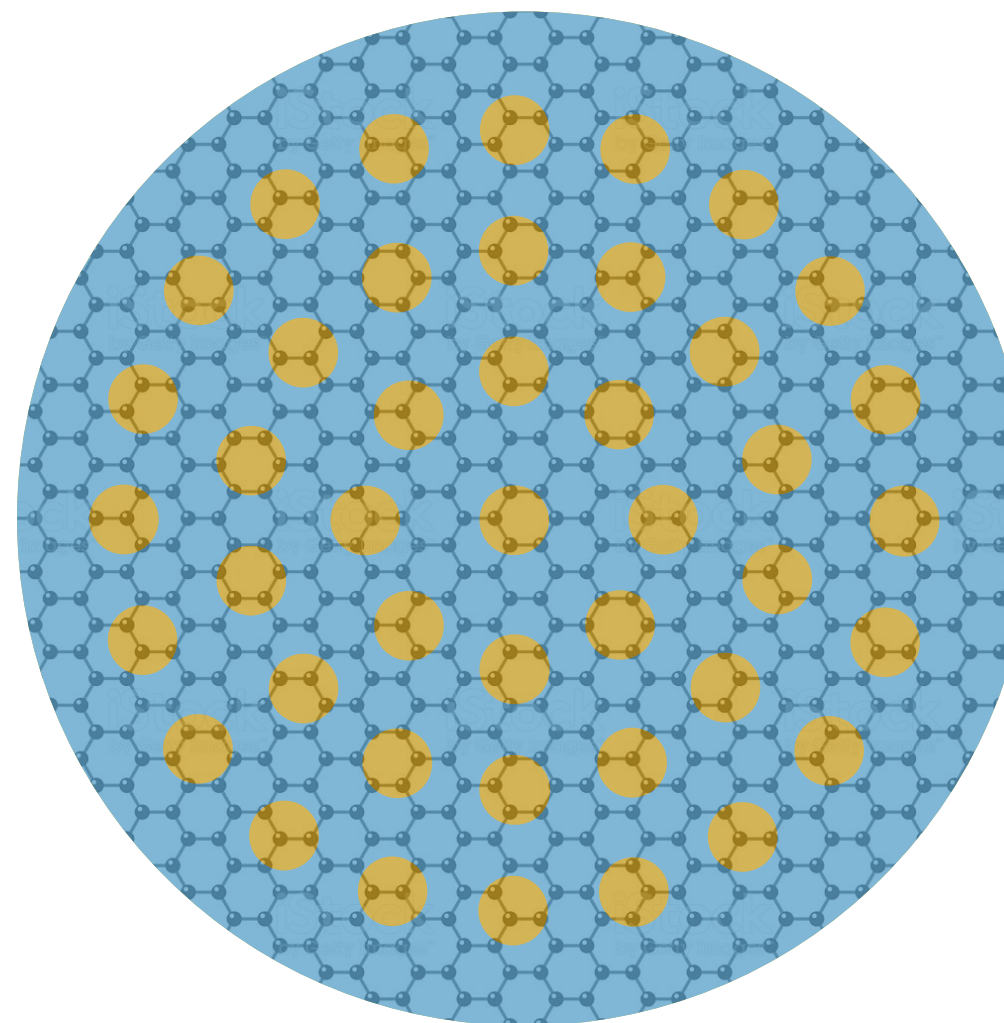
Primary electron energy 90 eV



# EELS on monolayer: suspended graphene



Monolayer graphene			
Component	Energy loss [eV]	Area	FWHM [eV]
$\pi_1$ -plasmon	6.9	143	2.3
$\pi_2$ -plasmon	5.9	87	1.7

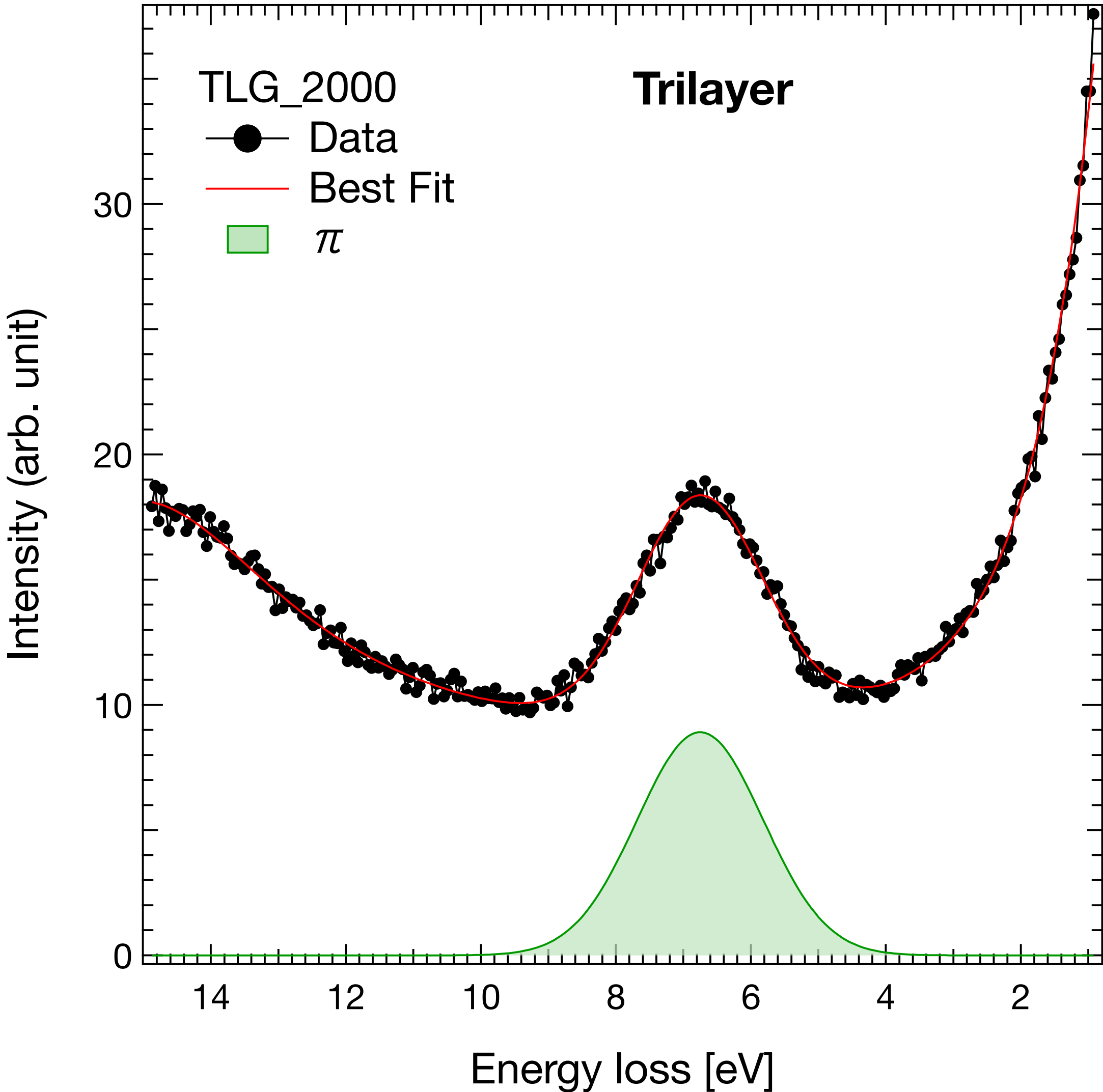


$$\frac{A_{\pi_2}}{A_{\pi_1} + A_{\pi_2}} = 38\%$$

Keep in mind this number,  
we'll see later on!



# EELS on trilayer: $\pi$ -plasmon energy shifted



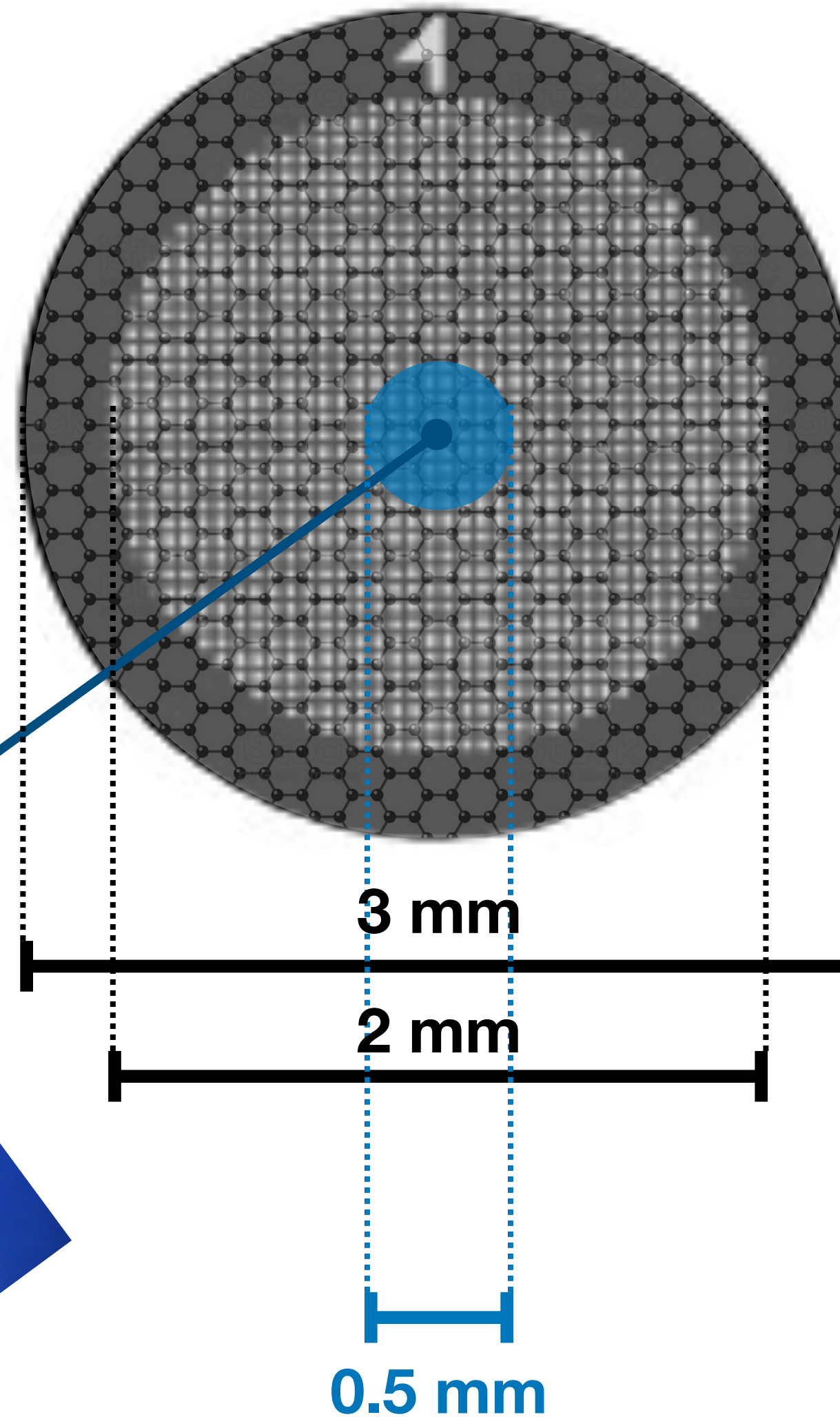
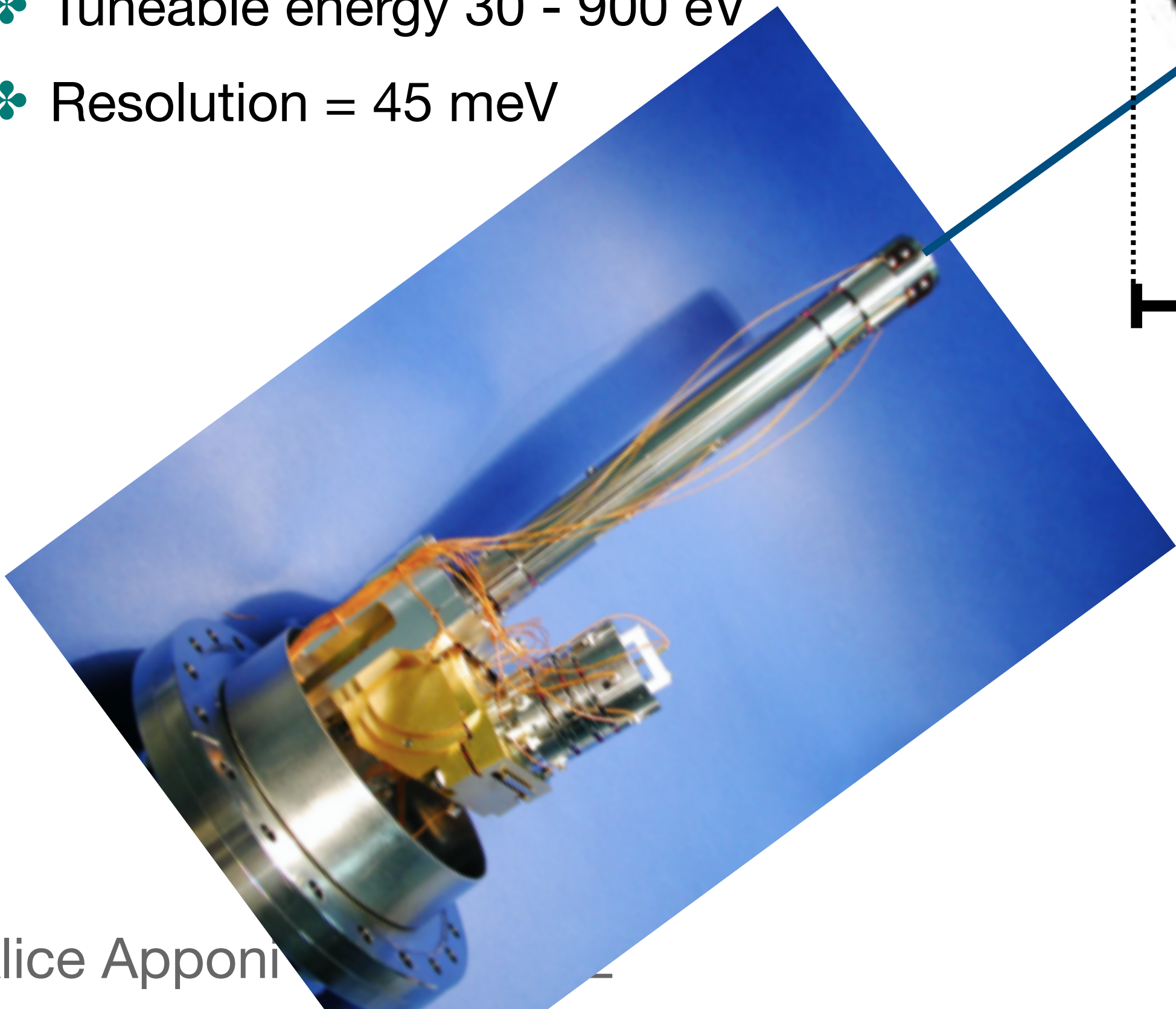
Trilayer graphene			
Component	Energy loss [eV]	Area	FWHM [eV]
$\pi$ -plasmon	6.8	410	2.2

$\pi$ -plasmon energy shifted increasing  
the number of graphene layers  
~1 eV wrt monolayer

# Transmission measurement: average on several grid holes

Monochromatic electron gun:

- ✿ Continuous electron beam
- ✿ Tuneable energy 30 - 900 eV
- ✿ Resolution = 45 meV

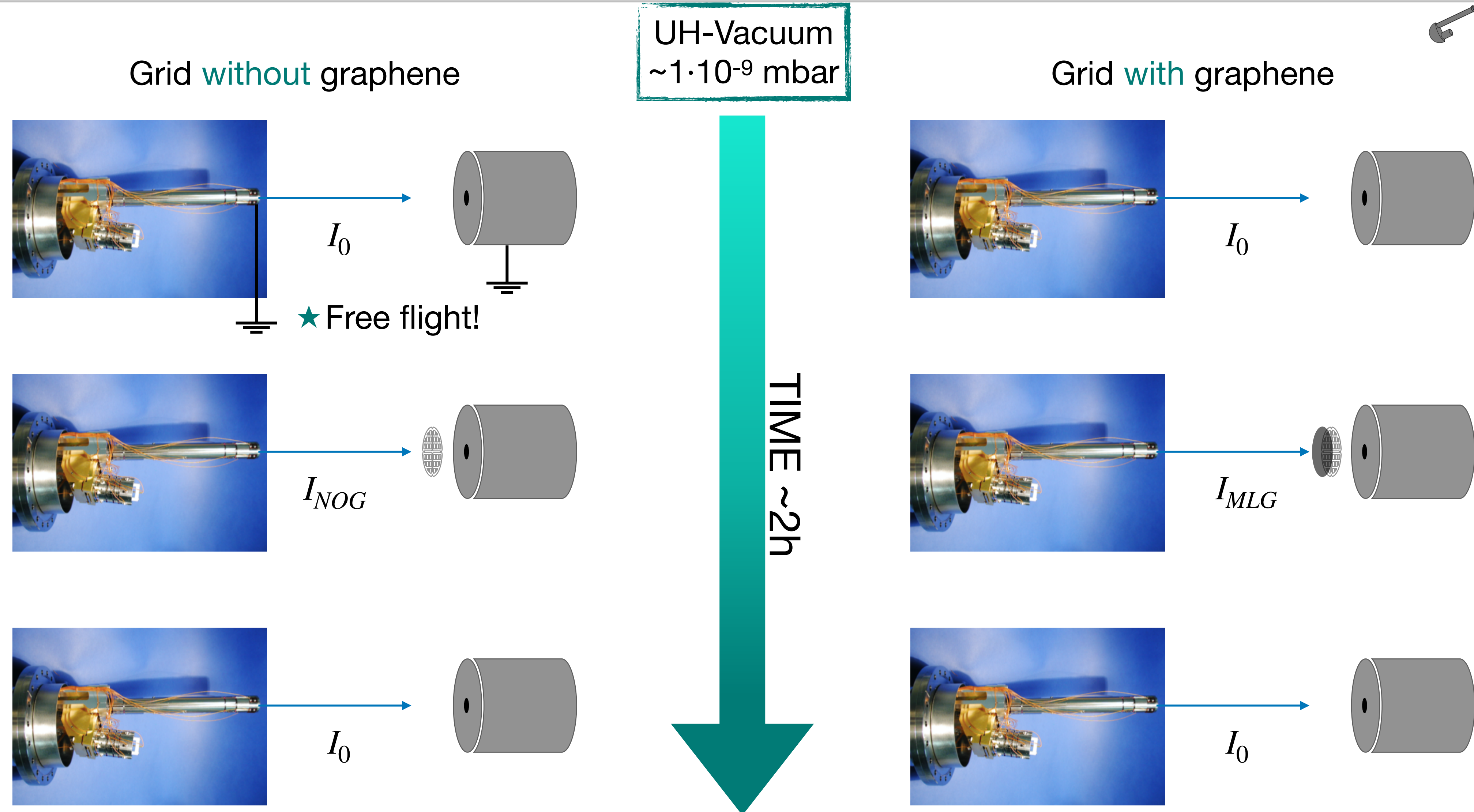


Dimension outline:

- ✿ Diameter 3 mm
- ✿ Effective diameter 2 mm
- ✿ 2000 mesh per inch  $\rightarrow$  12.5  $\mu\text{m}$  pitch
- ✿ Hole width 6.5  $\mu\text{m}$
- ✿ Beam size  $\sim$  0.5 mm

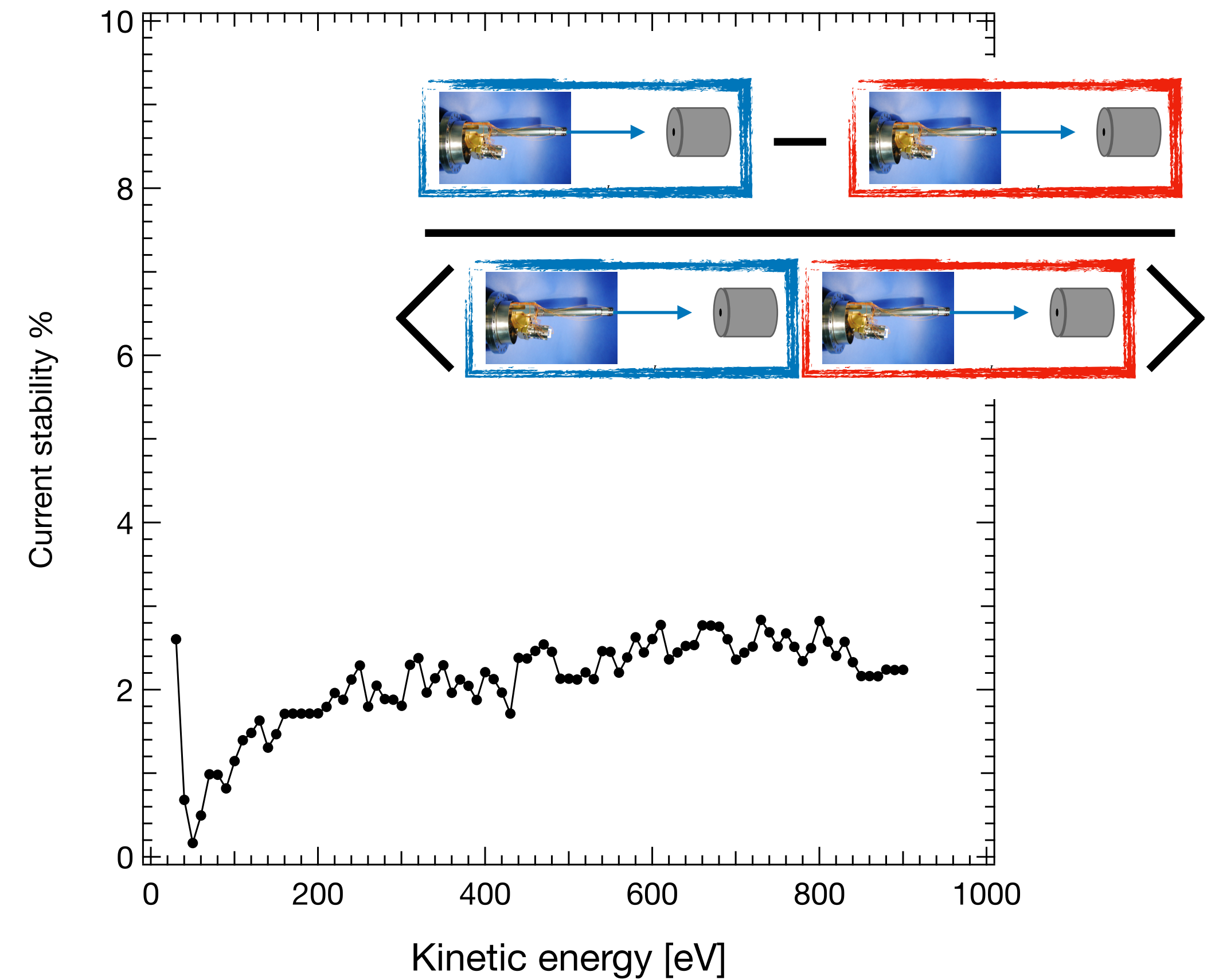
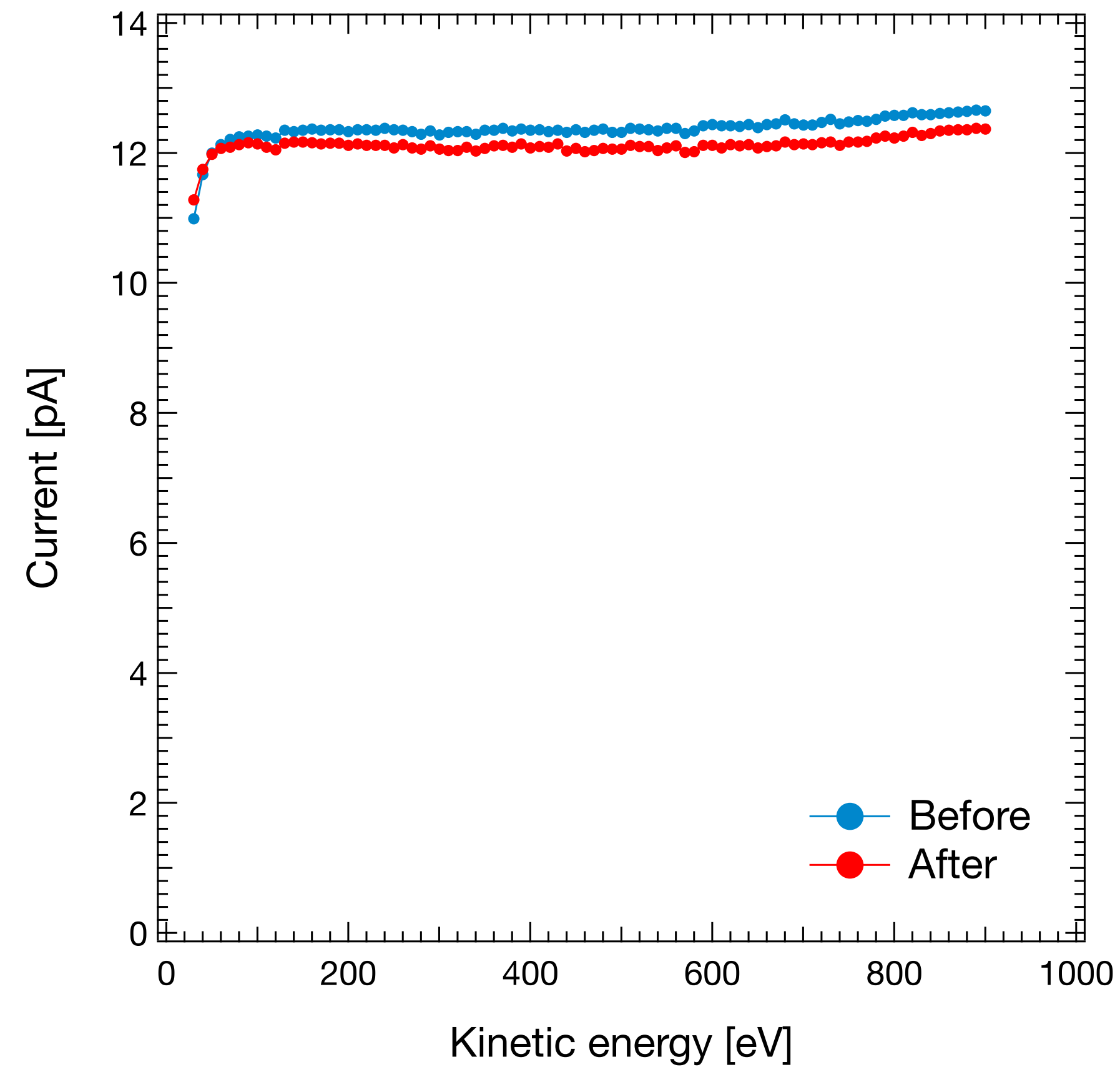


# Transmission measurement: the method



❖ Check stability with current measurement before and after

# Current stability < 3%



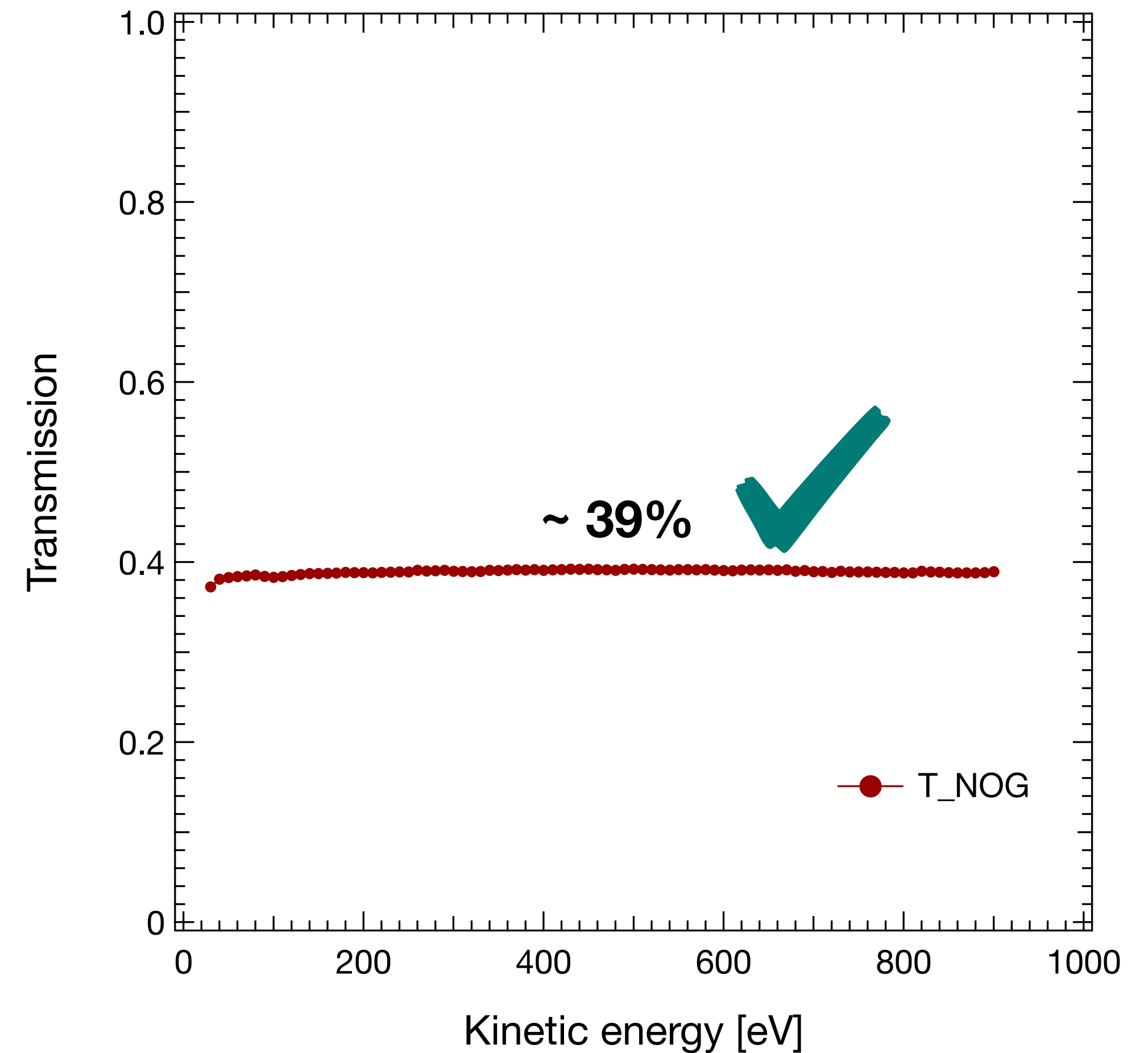
- ❖ Current stability  $\rightarrow$  before - after difference / average
- ❖ Picoammeter accuracy 0.5%
- ❖ Uncertainty essentially due to current stability



# Transmission of grid without graphene ~ 39%

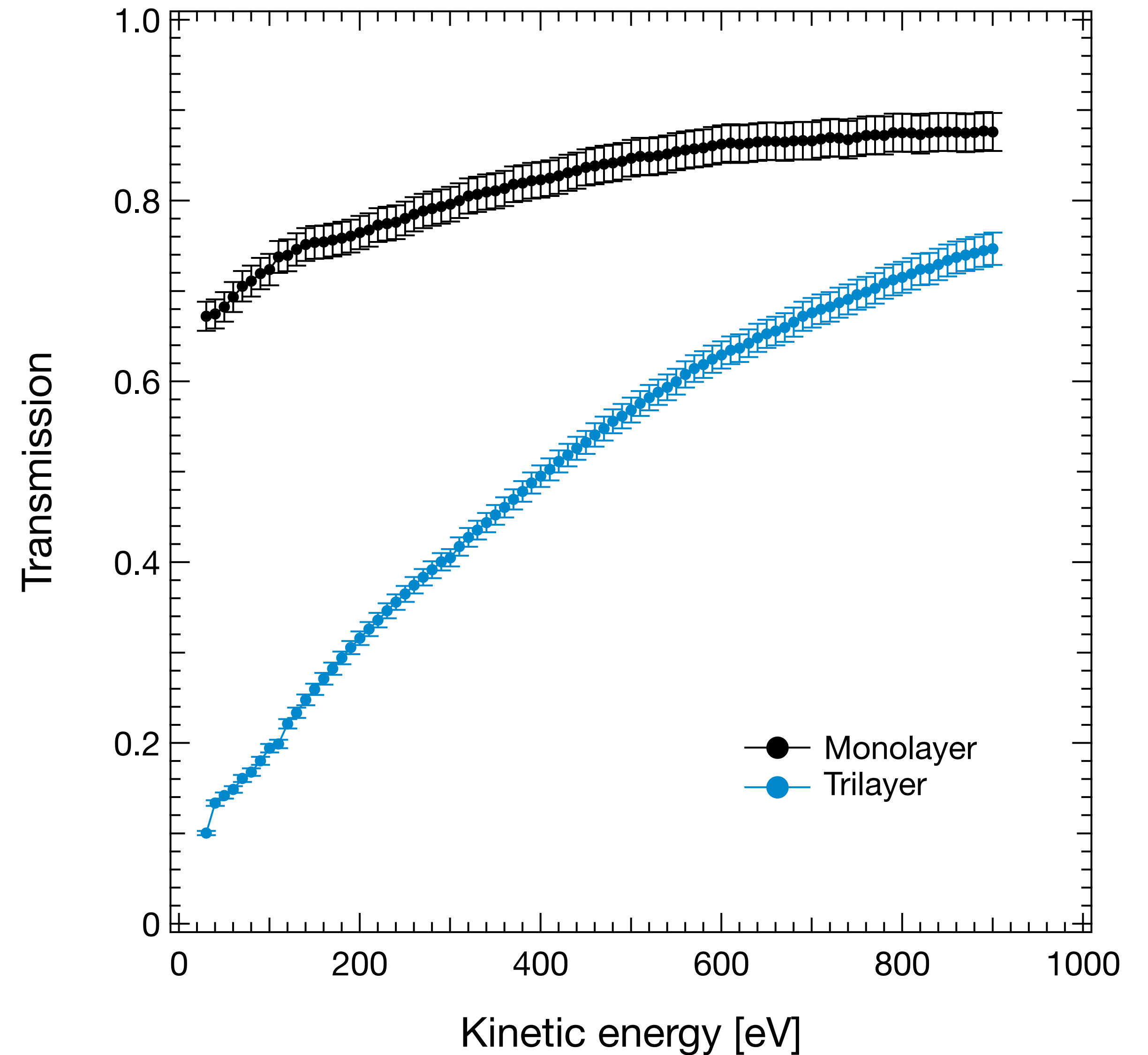
$\frac{I_{NOG}}{I_0}$  → grid without graphene (i.e. geometrical transmission)

- ✿ Nominal geometrical transmission 41 %
- ✿ Uncertainty 1.7% (not shown ~same size of the dots)



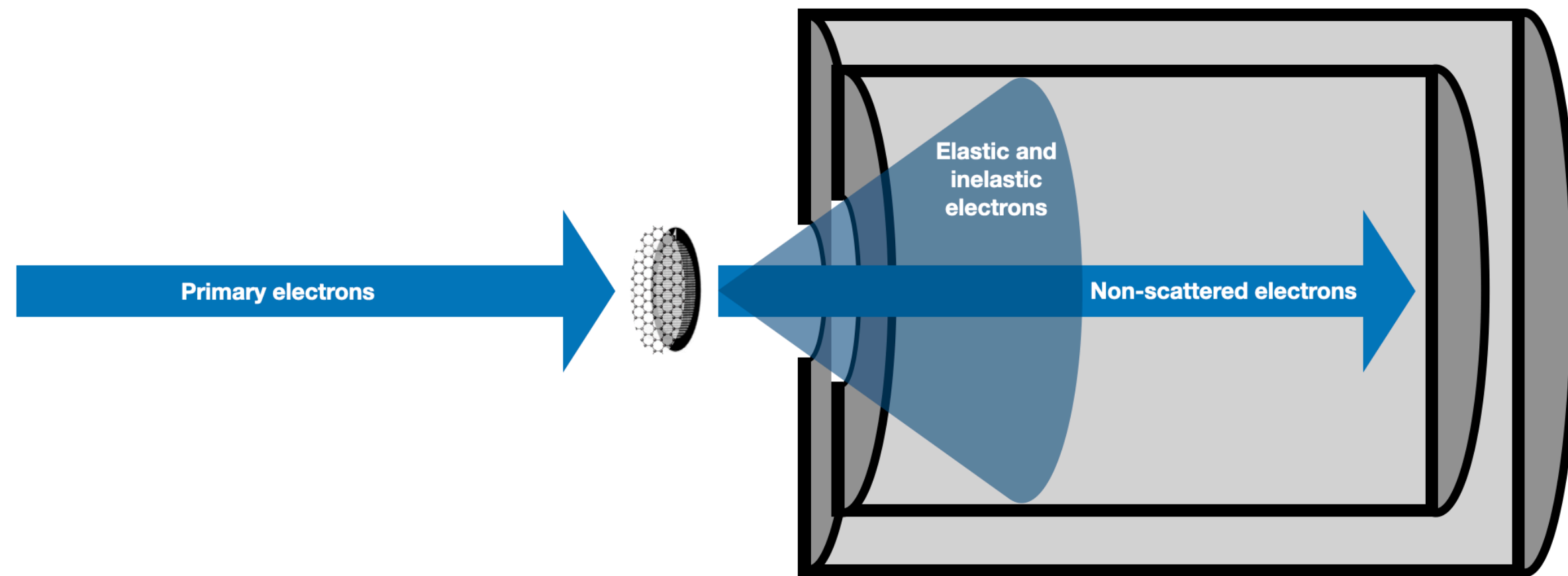
# Transmission through mono- and tri- layer graphene

$\frac{I_{xLG}}{I_0 \cdot 0.39} \longrightarrow$  grid with graphene (net of the  
39% grid transparency )





# Monolayer: elastically scattered electrons less than 8%



$N_s$  = # elastically scattered electrons

$N_i$  = # incident electrons

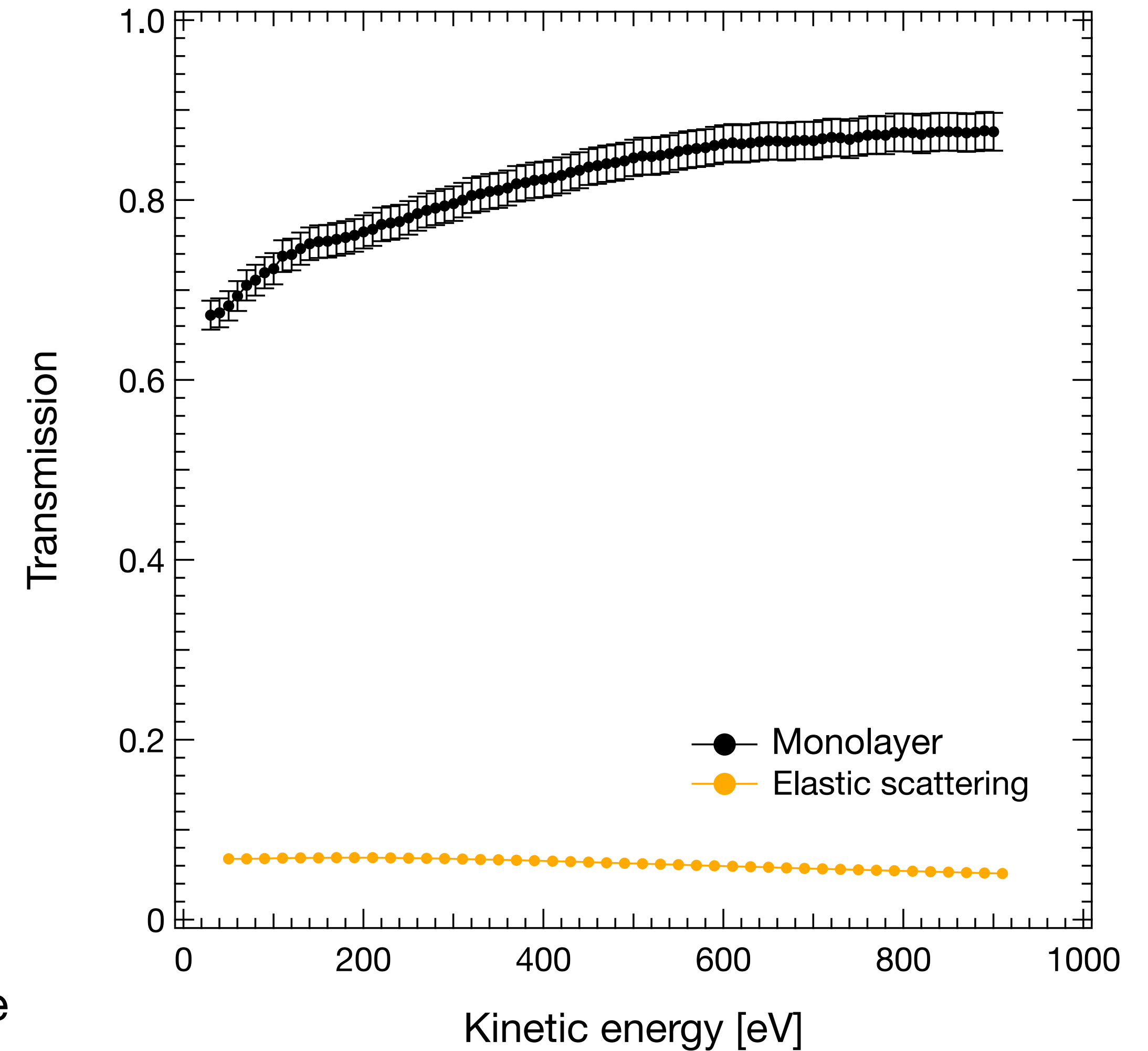
$$\frac{N_s}{N_i} = n_a f_g 2\pi \int_{\theta} \left( \frac{d\sigma}{d\Omega}(\theta) \right) \sin \theta d\theta$$

Carbon atom density  
 $39 \text{ nm}^{-2} = 0.11 a_0^{-2}$

Geometrical factor  
 39%

Taken from NIST database

[A. Jablonski, F. Salvat, C. J. Powell and A. Y. Lee, NIST Electron Elastic-Scattering Cross-Section Database Version 4.0. NIST Standard Reference Database Number 64, National Institute of Standards and Technology, Gaithersburg, MD, 20899, 2016]



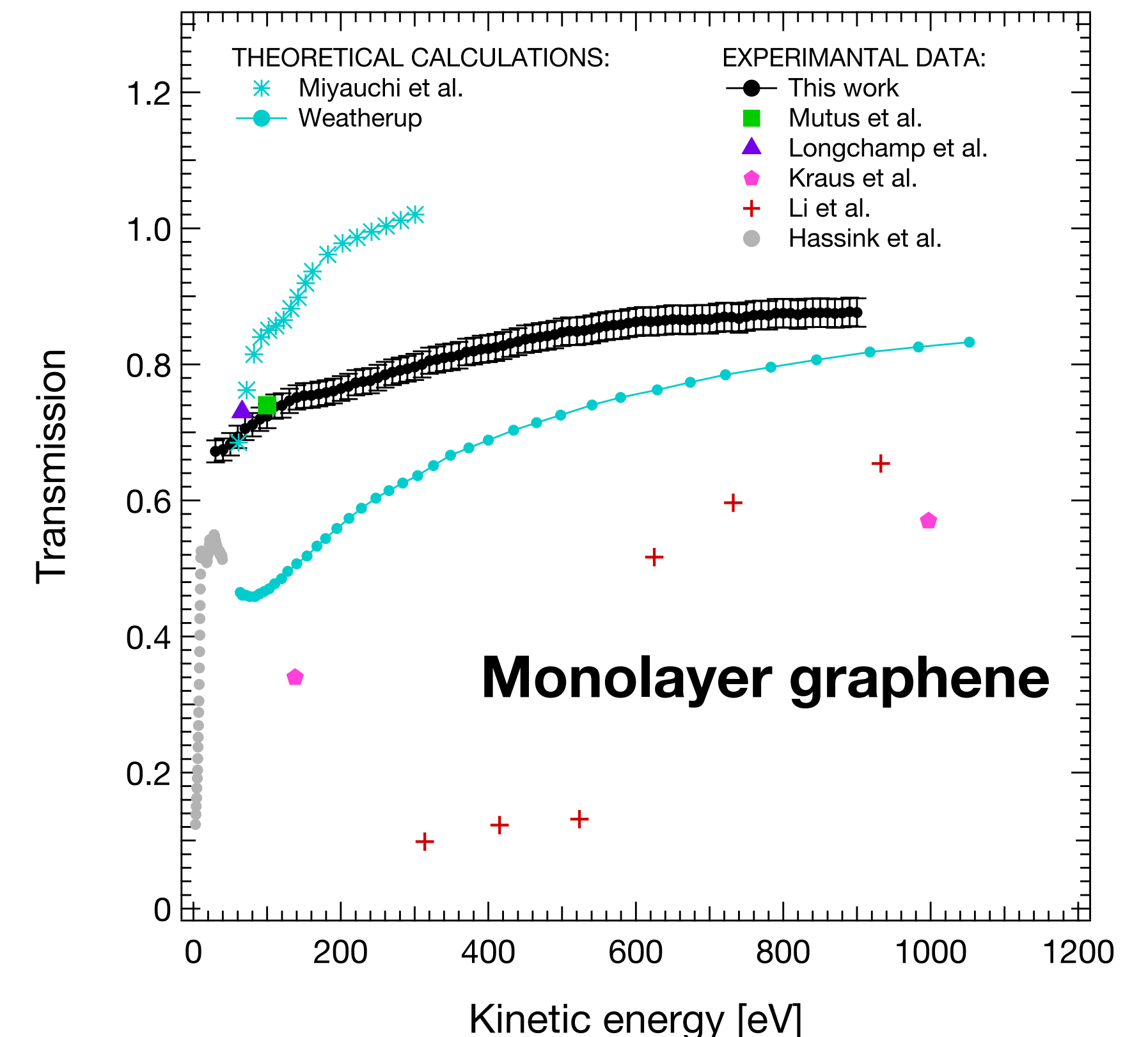
# To conclude

Graphene characterisation with spectroscopy:

- ❖ Contaminants removed with 500°C in-vacuum annealing
- ❖ High quality graphene, C 1s mainly  $sp_2$
- ❖ Evidence of suspended monolayer graphene (38%  $\pi$ -plasmon ratio, 39% measured open area!)
- ❖ Energy shifted  $\pi$ -plasmon for trilayer graphene

Transmission of low-energy electrons (30-900 eV):

- ❖ Experimental gap filled
- ❖ 70% to 90% transmission through monolayer graphene
- ❖ 10% to 80% transmission through trilayer graphene
- ❖ Main contribution to the transmitted beam through monolayer due to non-scattered electrons





# Graphene On meSH collaboration - GOSH

Alice Apponi, Università Roma Tre and INFN Roma3

Domenica Convertino, IIT Pisa

Neeraj Mishra, IIT Pisa

Camilla Coletti, IIT Pisa

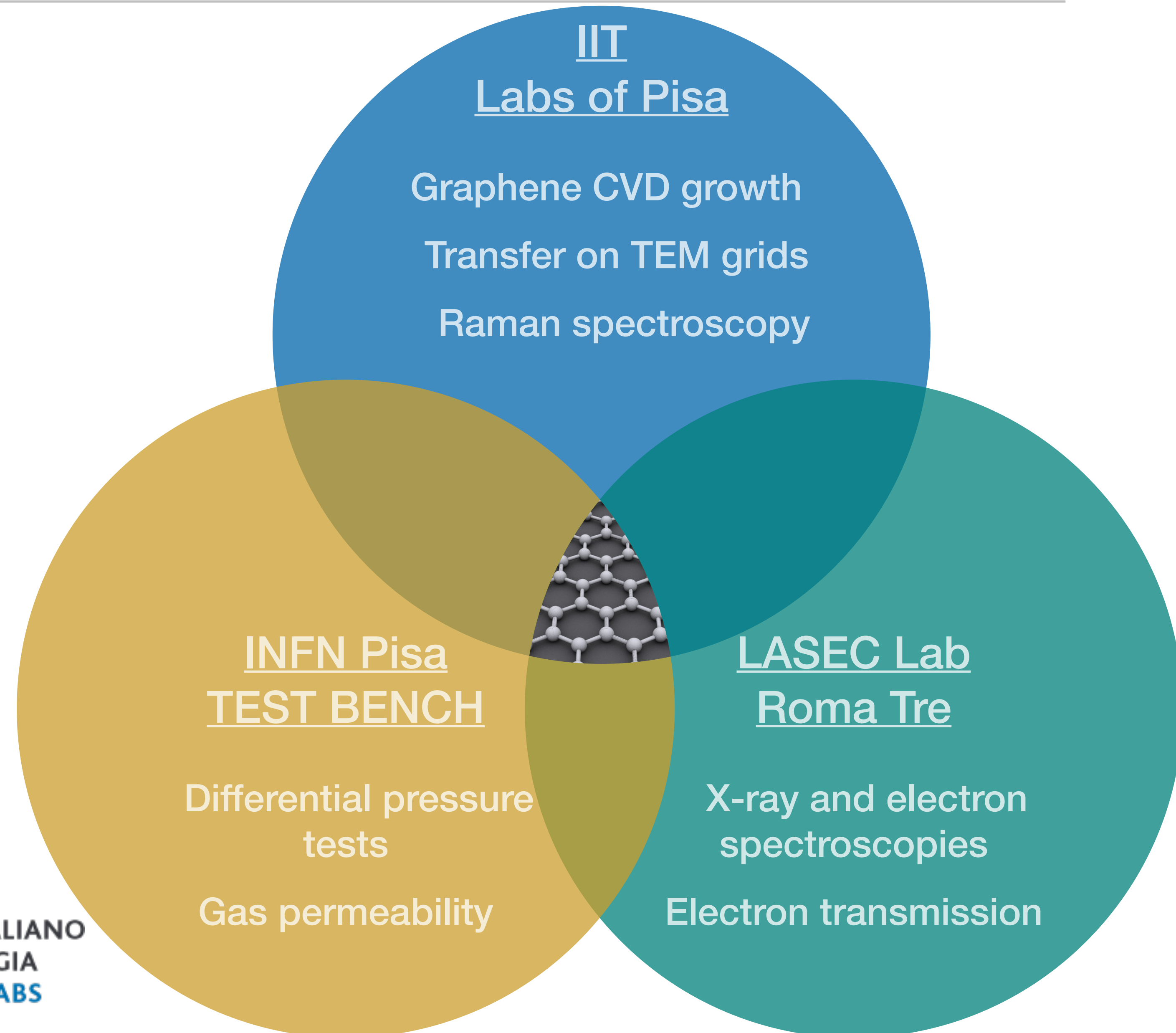
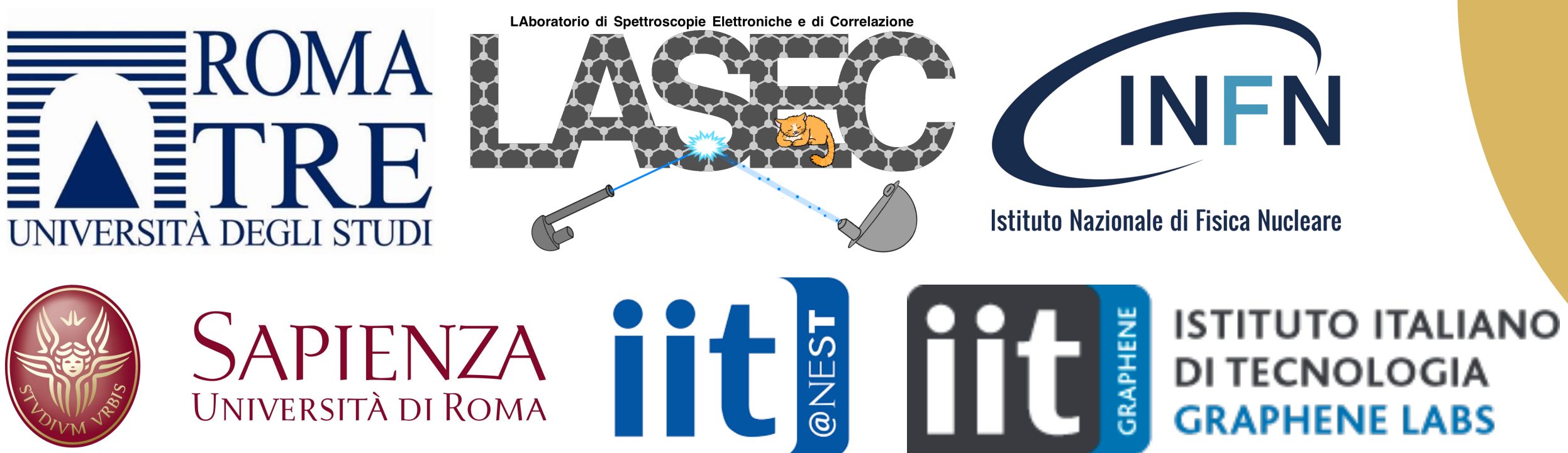
Mauro Iodice, INFN Roma3

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Alessandro Ruocco, Università Roma Tre and INFN Roma3



## **Backup slides**